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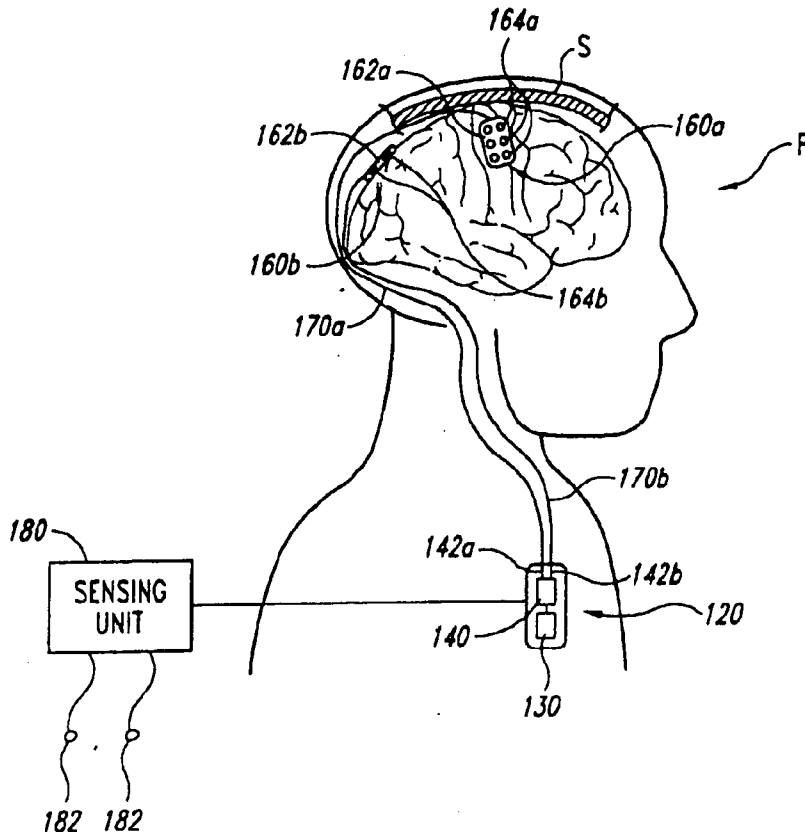
(57) **ABSTRACT**

Systems and methods for neural stimulation may include a stimulus unit; a first electrode assembly having a first set of contacts; and a second set of contacts. The stimulus unit can be an implantable pulse generator including a first terminal that can be biased at a first signal polarity and a second terminal that can be biased at a second signal polarity. The first electrode assembly includes a support member configured to be placed at the stimulation site, the first set of contacts carried by the support member, and a first lead configured to be attached to the first terminal of the implantable pulse generator for biasing the surface contacts at the first polarity. The second set of contacts is detached from the surface electrode assembly. The second set of contacts can be one or more conductive elements fixed to or forming portions of the implantable pulse generator, or a separate electrode array.

(22) Filed: **Mar. 15, 2006**

Related U.S. Application Data

(63) Continuation of application No. 10/910,775, filed on Aug. 2, 2004.



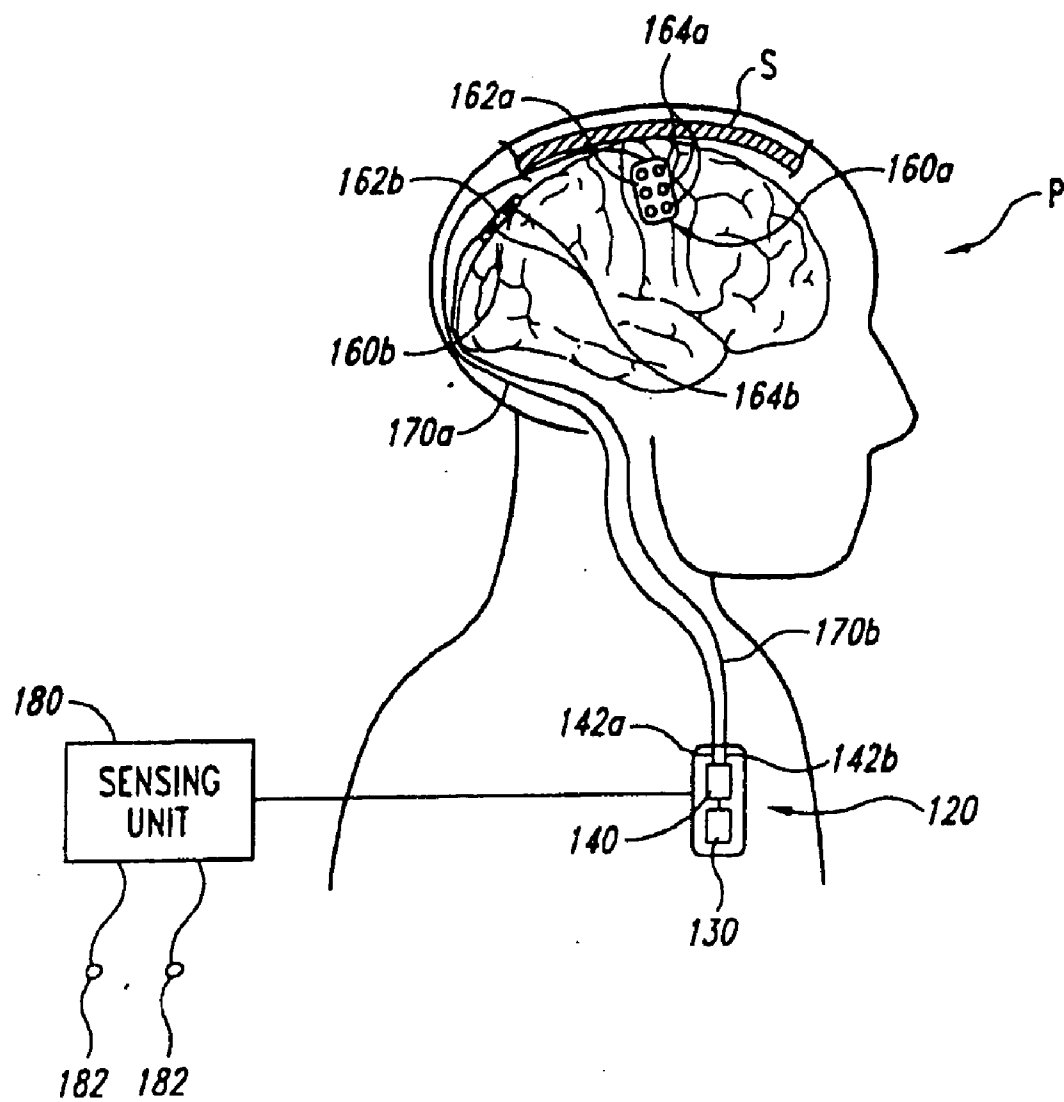


Fig. 1

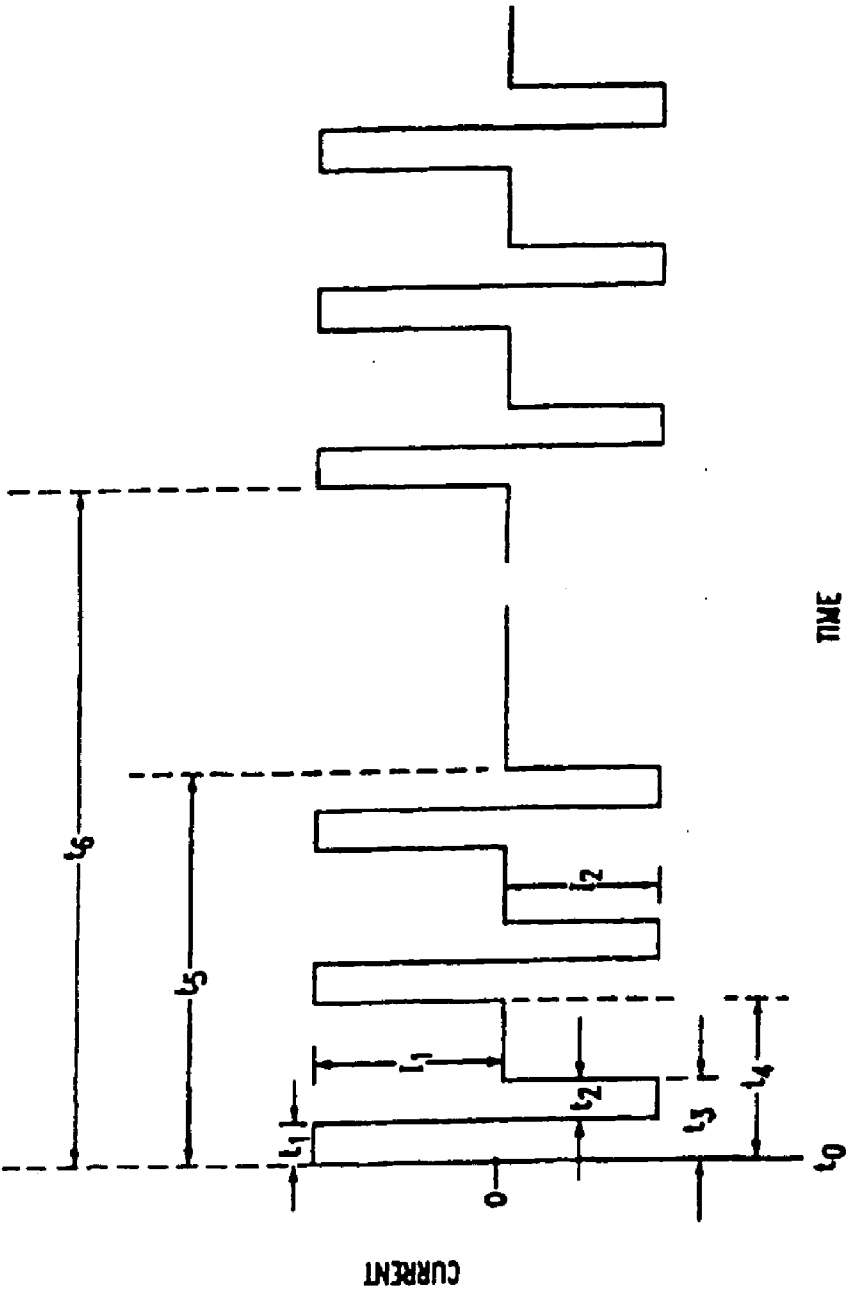
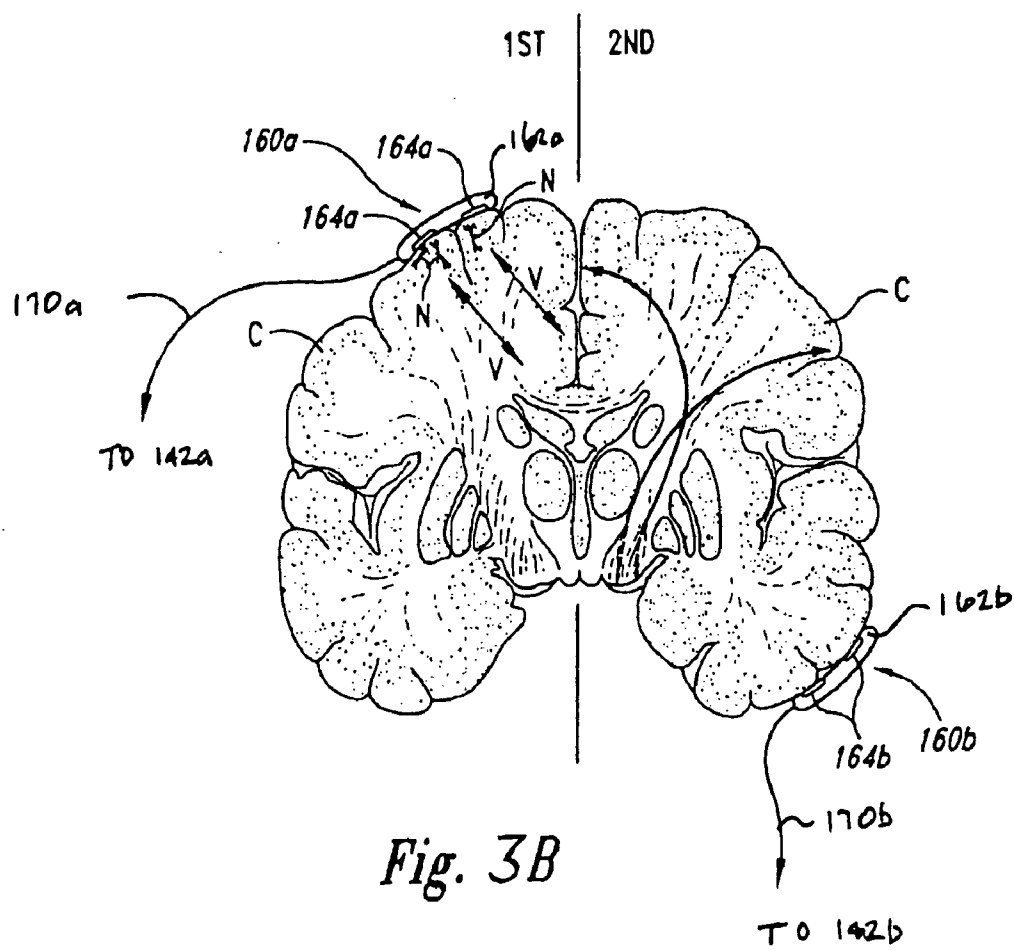
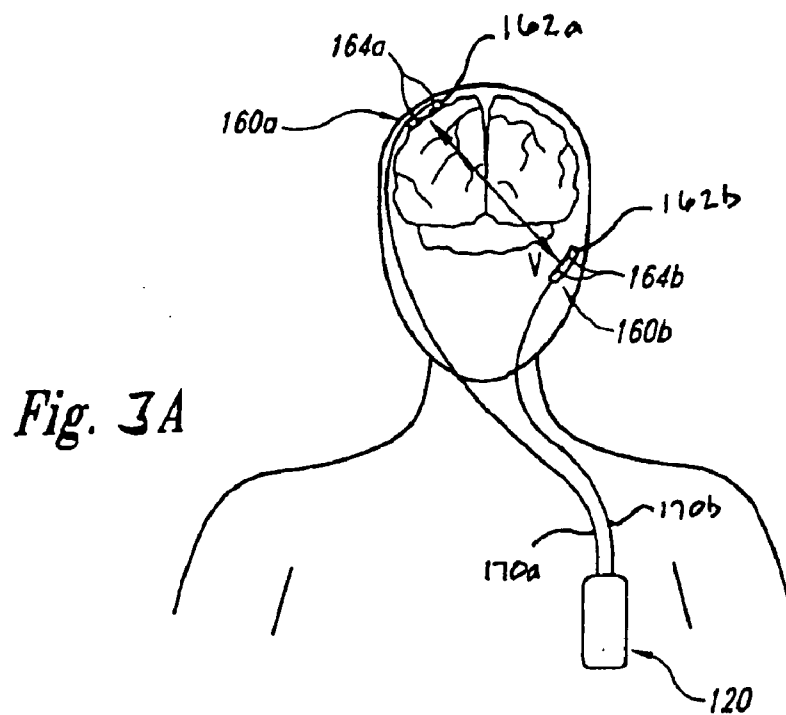


Fig. 2



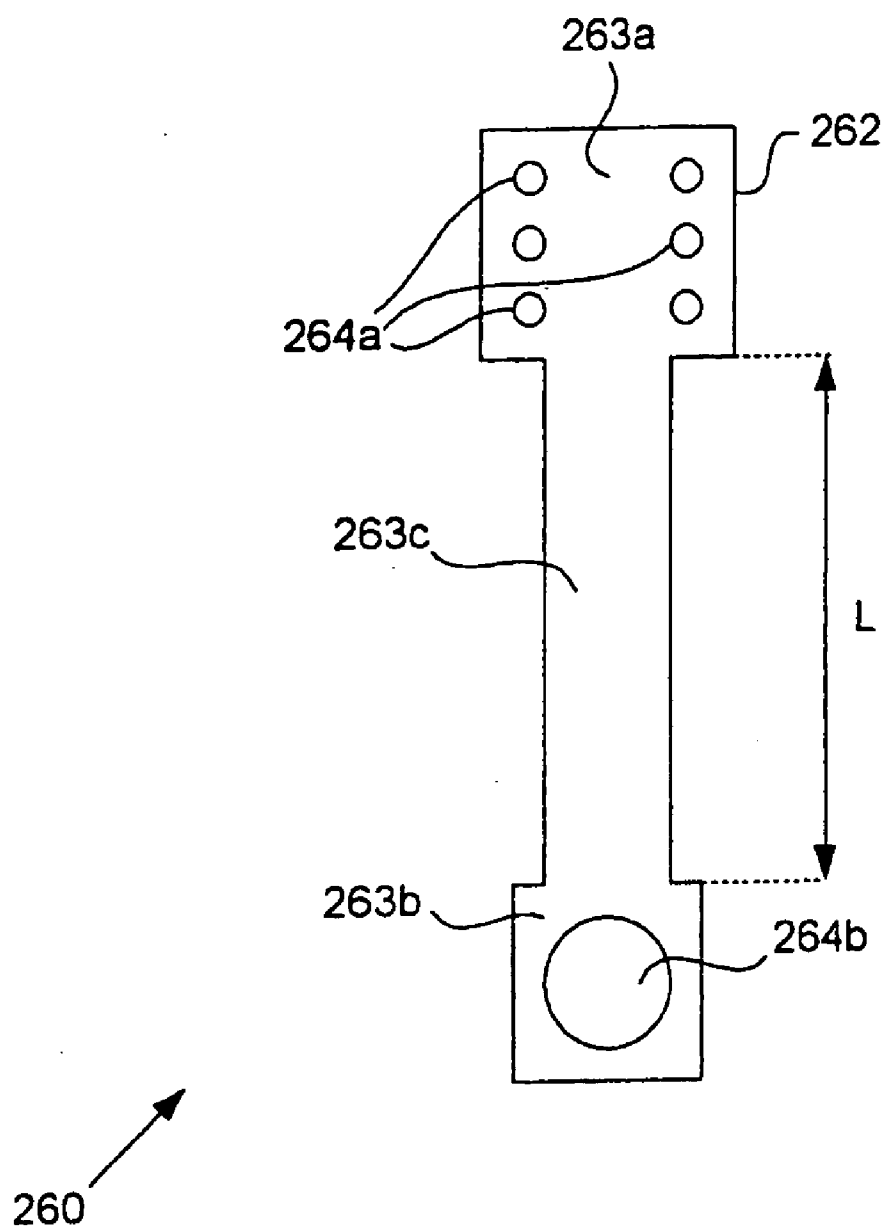


FIG. 3C

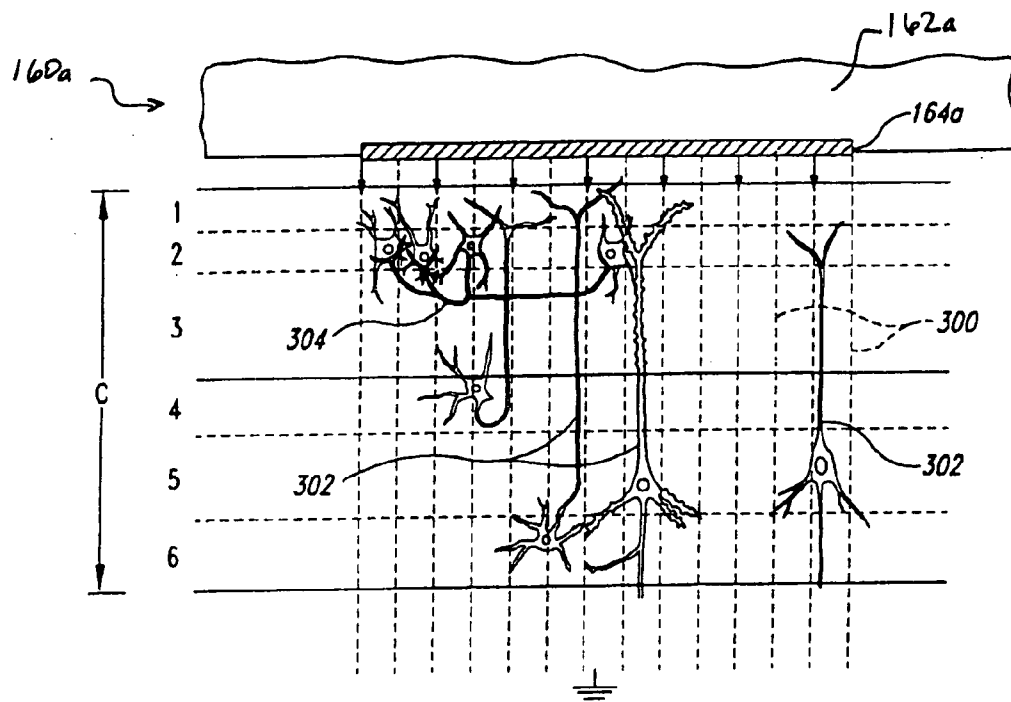


Fig. 4

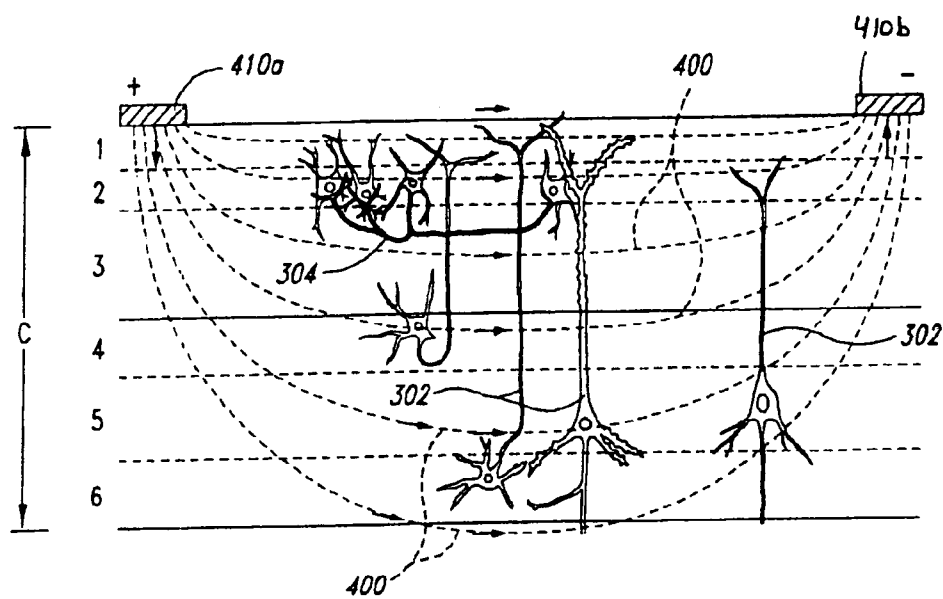


Fig. 5

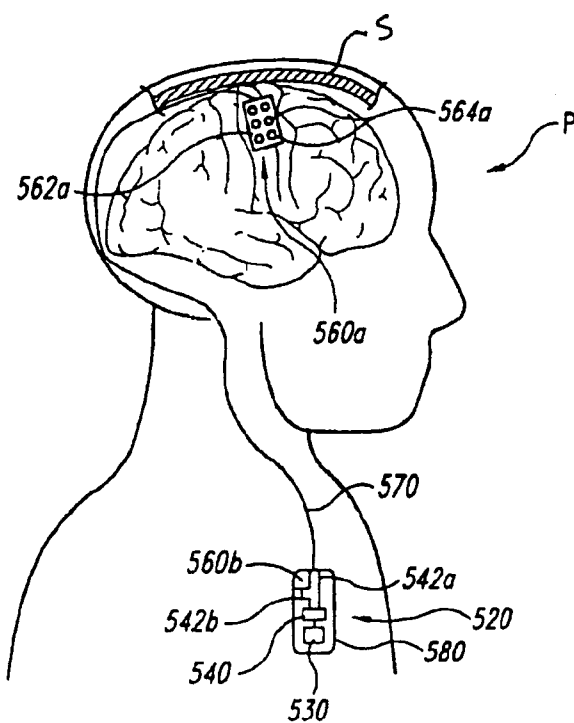


Fig. 6

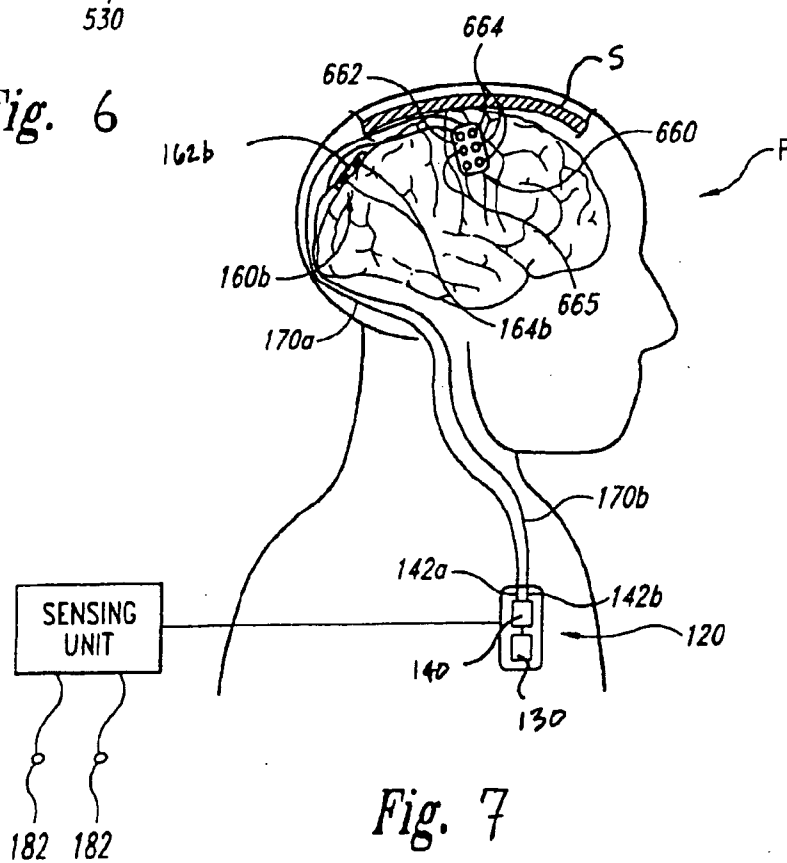


Fig. 7

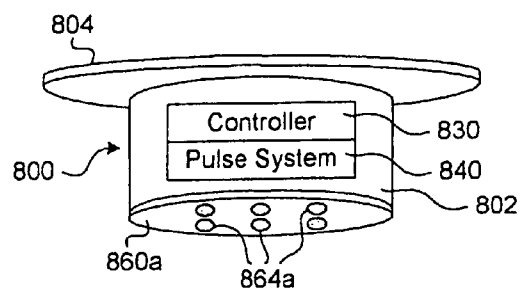


FIG. 8A

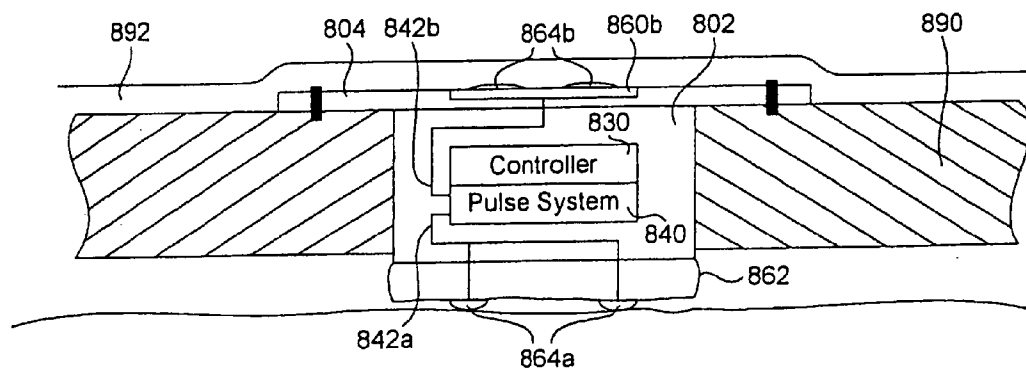


FIG. 8B

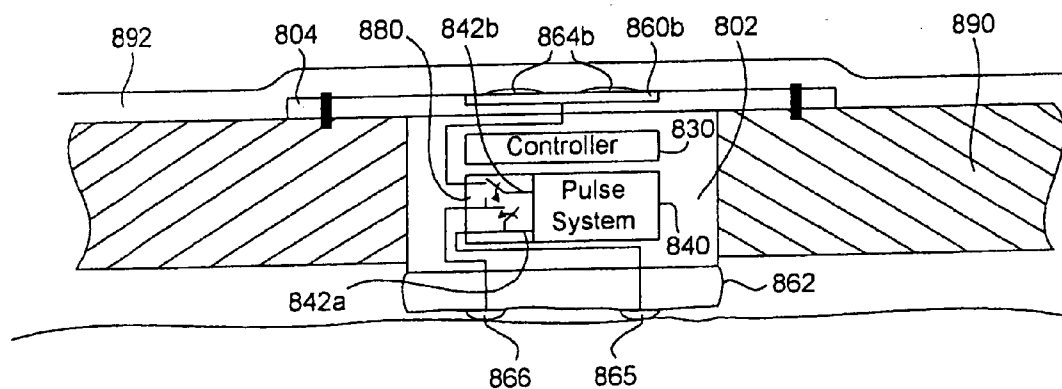


FIG. 8C

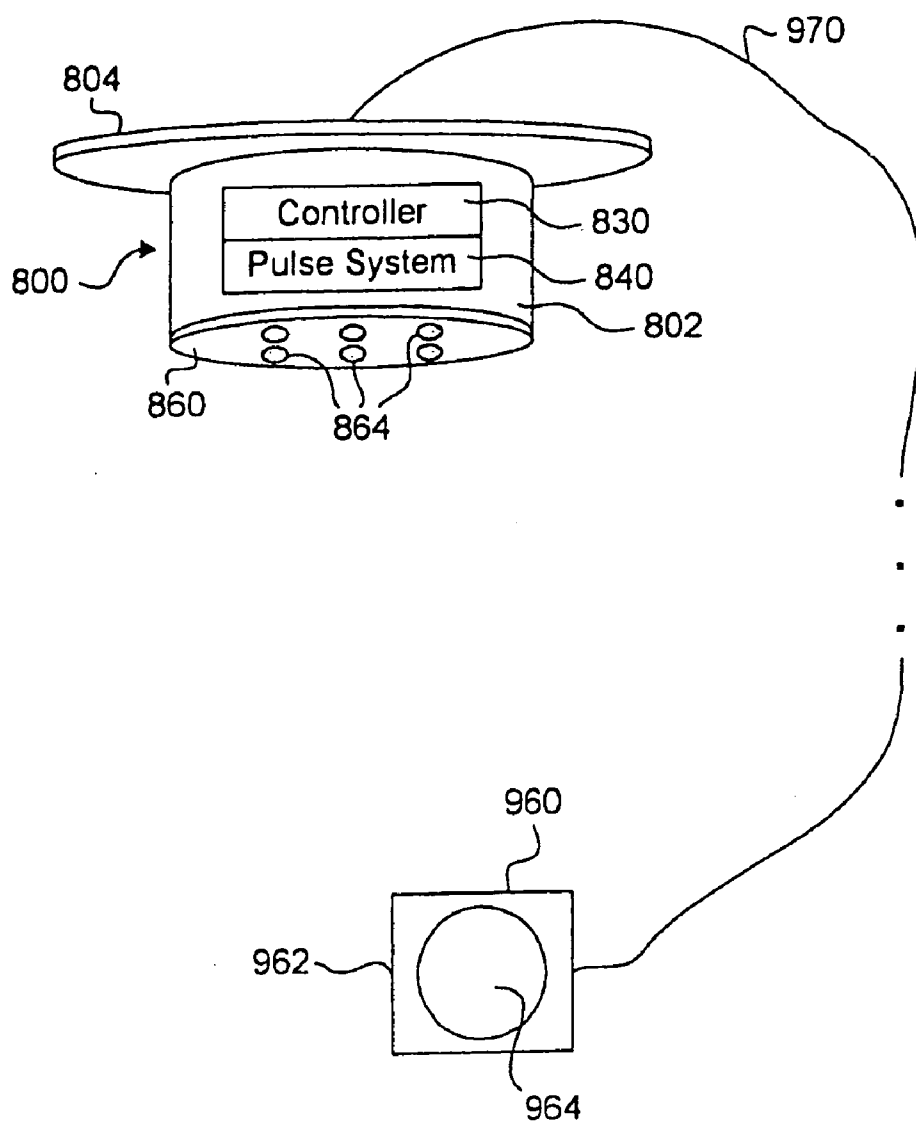


FIG. 9A

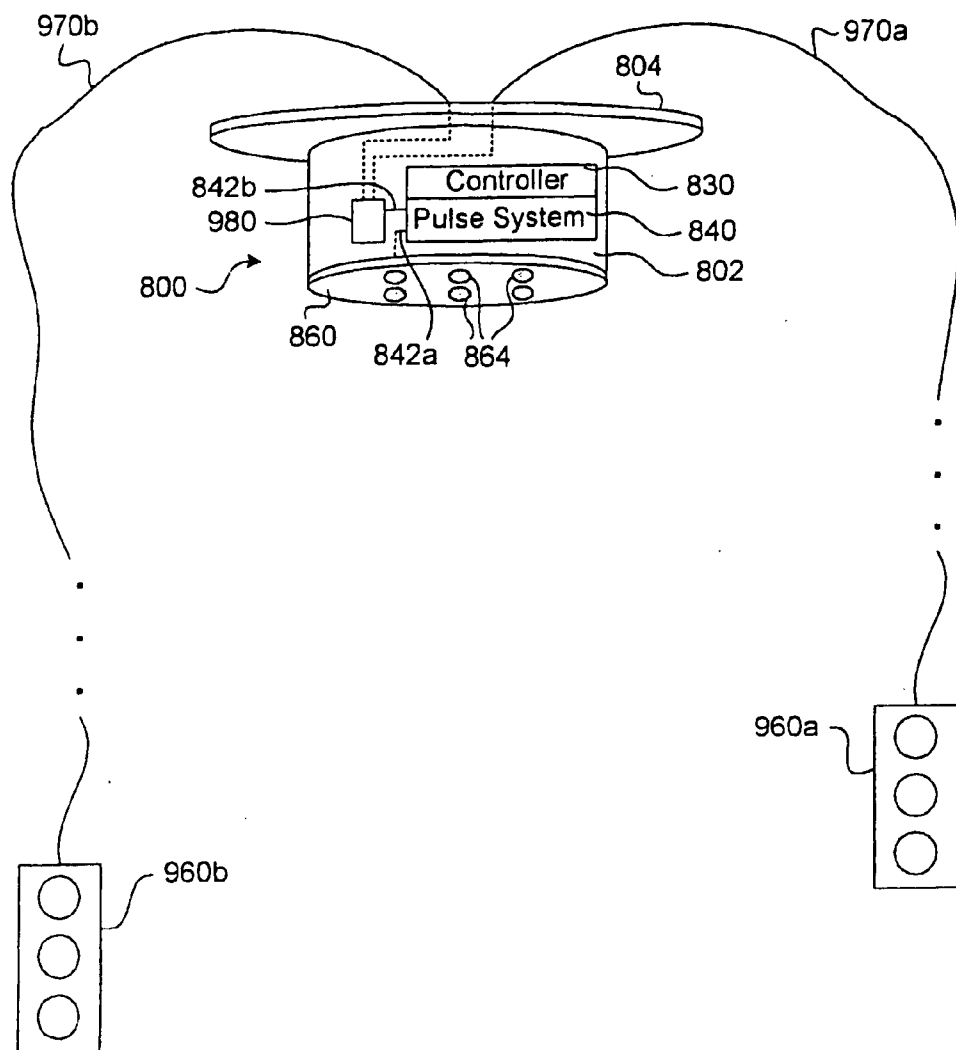


FIG. 9B

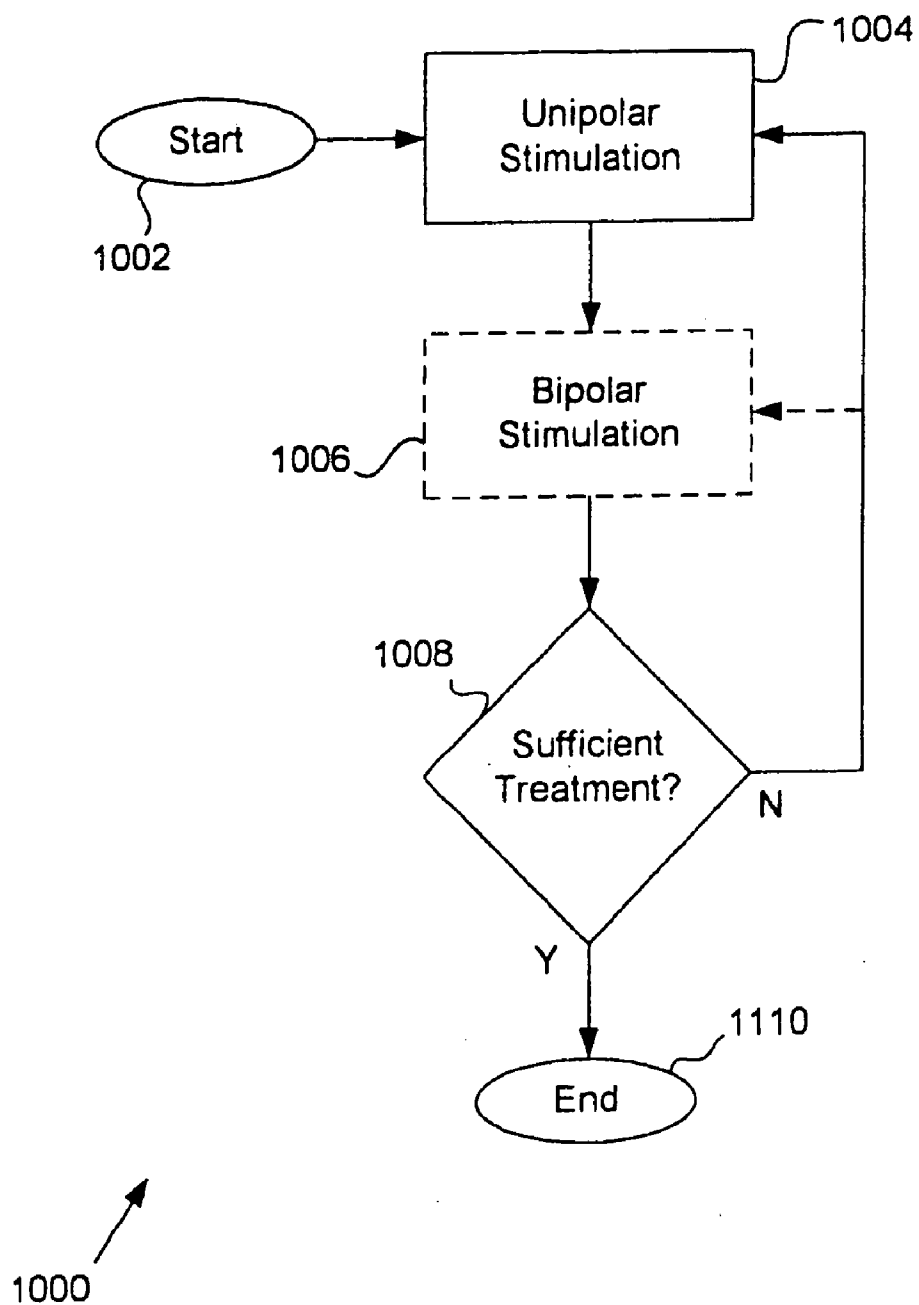


FIG. 10

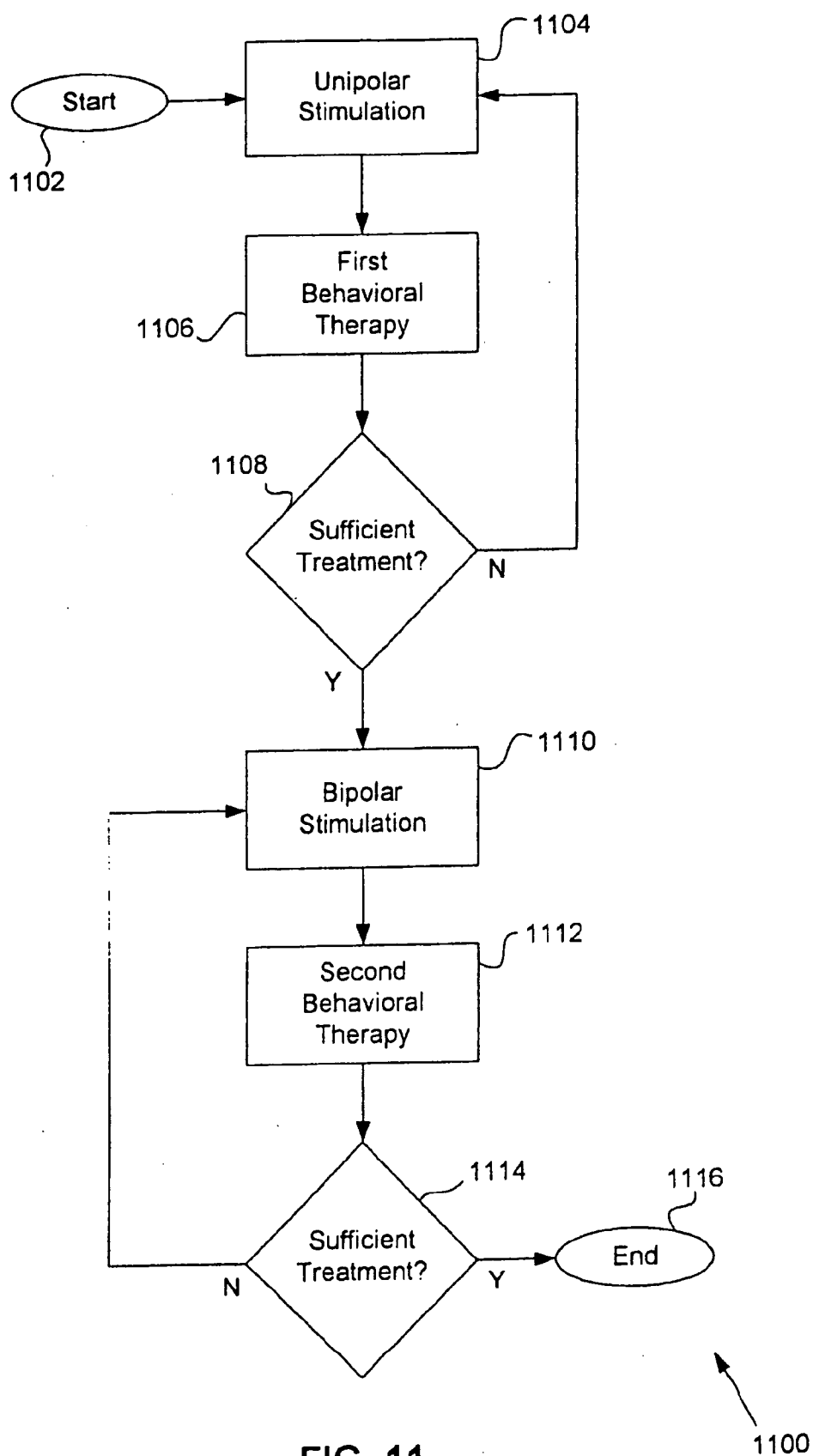


FIG. 11

APPARATUS AND METHODS FOR APPLYING NEURAL STIMULATION TO A PATIENT

CROSS-REFERENCE TO RELATED APPLICATIONS

[0001] This application claims priority to pending U.S. Provisional Application No. 60/492,273, filed on Aug. 1, 2003, and incorporated herein in its entirety by reference.

INCORPORATION OF RELATED APPLICATIONS

[0002] This application is related to U.S. patent application Ser. No. 09/802,808 entitled "Methods and Apparatus for Effectuating a Lasting Change in a Neural-Function of a Patient," which claims the benefit of U.S. Provisional Application 60/217,981, filed Jul. 31, 2000, both of which are herein incorporated by reference. Additional applications are incorporated by reference in other portions of this application.

TECHNICAL FIELD

[0003] The present disclosure is related to systems and methods for applying stimulation to a target neural population within a patient, for example, a surface site on the patient's cortex.

BACKGROUND

[0004] A wide variety of mental and physical processes are controlled or influenced by neural activity in particular regions of the brain. The neural-functions in some areas of the brain (i.e., the sensory or motor cortices) are organized according to physical or cognitive functions, and various areas of the brain appear to have distinct functions in most individuals. In the majority of people, for example, the occipital lobes relate to vision, the left interior frontal lobes relate to language, and the cerebral cortex appears to be involved with conscious awareness, memory, and intellect.

[0005] Many problems or abnormalities can be caused by damage, disease and/or disorders in the brain. Effectively treating such abnormalities may be very difficult. For example, a stroke is a common condition that damages the brain. Strokes are generally caused by emboli (e.g., obstruction of a vessel), hemorrhages (e.g., rupture of a vessel), or thrombi (e.g., clotting) in the vascular system of a specific region of the brain. Such events generally result in a loss or impairment of a neural function (e.g., neural functions related to facial muscles, limbs, speech, etc.). Stroke patients are typically treated using various forms of physical therapy to rehabilitate the loss of function of a limb or another affected body part. Stroke patients may also be treated using physical therapy plus an adjunctive therapy such as amphetamine treatment. For most patients, however, such treatments are minimally effective and little can be done to improve the function of an affected body part beyond the recovery that occurs naturally without intervention.

[0006] Neurological problems or abnormalities are often related to electrical and/or chemical activity in the brain. Neural activity is governed by electrical impulses or "action potentials" generated in neurons and propagated along synaptically connected neurons. When a neuron is in a quiescent state, it is polarized negatively and exhibits a resting membrane potential typically between -70 and -60 mV. Through

chemical connections known as synapses, any given neuron receives excitatory and inhibitory input signals or stimuli from other neurons. A neuron integrates the excitatory and inhibitory input signals it receives, and generates or fires a series of action potentials when the integration exceeds a threshold potential. A neural firing threshold, for example, may be approximately -55 mV.

[0007] It follows that neural activity in the brain can be influenced by electrical energy supplied from an external source such as a waveform generator. Various neural functions can be promoted or disrupted by applying an electrical current to the cortex or other region of the brain. As a result, researchers have attempted to treat physical damage, disease and disorders in the brain using electrical or magnetic stimulation signals to control or affect brain functions.

[0008] Transcranial electrical stimulation is one such approach that involves placing an electrode on the exterior of the scalp and delivering an electrical current to the brain through the scalp and skull. Another treatment approach, transcranial magnetic stimulation, involves producing a high-powered magnetic field adjacent to the exterior of the scalp over an area of the cortex. Yet another treatment approach involves direct electrical stimulation of neural tissue using implanted electrodes.

[0009] The neural stimulation signals used by these approaches may comprise a series of electrical or magnetic pulses directed toward affecting neurons within a target neural population. Stimulation signals may be defined or described in accordance with stimulation signal parameters including pulse amplitude, pulse frequency, duty cycle, stimulation signal duration, and/or other parameters. Electrical or magnetic stimulation signals applied to a population of neurons can depolarize neurons within the population toward their threshold potentials. Depending upon stimulation signal parameters, this depolarization can cause neurons to generate or fire action potentials. Neural stimulation that elicits or induces action potentials in a functionally significant proportion of the neural population to which the stimulation is applied is referred to as supra-threshold stimulation; neural stimulation that fails to elicit action potentials in a functionally significant proportion of the neural population is defined as sub-threshold stimulation. In general, supra-threshold stimulation of a neural population triggers or activates one or more functions associated with the neural population, but sub-threshold stimulation by itself does not trigger or activate such functions. Supra-threshold neural stimulation can induce various types of measurable or monitorable responses in a patient. For example, supra-threshold stimulation applied to a patient's motor cortex can induce muscle fiber contractions in an associated part of the body.

[0010] Although electrical or magnetic stimulation of neural tissue may be directed toward producing an intended type of therapeutic, rehabilitative, or restorative neural activity, such stimulation may result in collateral neural activity. In particular, neural stimulation delivered beyond a certain intensity, period of time, level, or amplitude can give rise to seizure activity and/or other types of collateral activity. It will be appreciated that certain types of collateral neural activity may be undesirable and/or inconvenient in a neural stimulation situation.

[0011] Another concern that arises in association with stimulating a surface site on a patient's cortex is conserva-

tion or minimization of applied power while operating a stimulation device. Various types of systems have an implanted pulse generator ("IPG") and an electrode assembly. The electrode assembly generally has a plurality of contacts that are carried by a common support member, such that the contacts are positionally fixed in close or generally close proximity relative to each other. In operation, the IPG delivers an electrical waveform to the electrode assembly, such that a first set of contacts provides a current delivery path and a second set of contacts provides a current return path. Thus, at any given time during waveform delivery, at least one contact has a positive bias and at least one contact has a negative bias, resulting in the generation of a bipolar field at the surface of the cortex within the area of the stimulation site. The bipolar field has a lower current density in the deeper layers of the cortex compared to the current density at the surface layers, and the bipolar field runs generally parallel to the cranium of the patient in the deeper layers of the cortex. Systems that generate a bipolar field at the stimulation site may require relatively high current levels to achieve an intended or desired therapeutic effect. This may result in increased power consumption, and possibly increase the likelihood of inducing collateral neural activity.

BRIEF DESCRIPTION OF THE DRAWINGS

[0012] **FIG. 1** is a side view of a system for applying electrical stimulation to a stimulation site on or proximate to the surface of the cortex of a patient in accordance with an embodiment of the invention.

[0013] **FIG. 2** is a graph illustrating several parameters that may describe, define, or characterize a stimulation signal.

[0014] **FIG. 3A** is a front view of a system for applying electrical stimulation to a cortical stimulation site in accordance with **FIG. 1A** showing a different implementation of the system.

[0015] **FIG. 3B** is a cross-sectional view of a brain of a patient illustrating the implementation of **FIG. 3A** in greater detail.

[0016] **FIG. 3C** is a schematic illustration of a combined electrode assembly that may be used to apply or deliver unipolar stimulation to a patient.

[0017] **FIG. 4** is a schematic illustration showing an exemplary electric field distribution generated by unipolar electrical stimulation using a system for applying electrical stimulation to a cortical stimulation site in accordance with an embodiment of the invention.

[0018] **FIG. 5** is a schematic illustration showing an exemplary electrical field distribution generated by bipolar electrical stimulation at a cortical stimulation site.

[0019] **FIG. 6** is a side view of a system for applying electrical stimulation to a cortical stimulation site in accordance with another embodiment of the invention.

[0020] **FIG. 7** is a side view of a system for applying electrical stimulation to a cortical stimulation site in accordance with another embodiment of the invention.

[0021] **FIGS. 8A and 8B** are an isometric view and a cross sectional view, respectively, of a system for applying elec-

trical stimulation to a site on or proximate to the cortex in accordance with another embodiment of the invention.

[0022] **FIG. 8C** is a cross sectional view of a system for applying electrical stimulation to a site on or proximate to the cortex according to another embodiment of the invention.

[0023] **FIG. 9A** is a schematic illustration of a system for applying electrical stimulation to a site on or proximate to the cortex in accordance with another embodiment of the invention.

[0024] **FIG. 9B** is a schematic illustration of a system for applying electrical stimulation to a site on or proximate to the cortex in accordance with another embodiment of the invention.

[0025] **FIGS. 10-11** are flow charts illustrating methods for applying electrical stimulation to a stimulation site in accordance with embodiments of the invention.

DETAILED DESCRIPTION

[0026] The present disclosure describes systems and methods for neural stimulation that may enhance the efficacy and/or increase the efficiency of neural stimulation procedures. The neural stimulation may comprise a set of stimulation signals applied or delivered to or through target neural structures, target neural projections, and/or one or more target neural populations associated with controlling, influencing, or affecting one or more neurological functions under consideration. The neural stimulation may be directed toward facilitating and/or effectuating at least some degree of symptomatic relief and/or restoration or development of functional abilities in patients experiencing neurologic dysfunction arising from neurological damage, neurologic disease, neurodegenerative conditions, neuropsychiatric disorders, cognitive or learning disorders, and/or other conditions. Such neurologic dysfunction may correspond to Parkinson's Disease, essential tremor, Huntington's disease, stroke, traumatic brain injury, Cerebral Palsy, Multiple Sclerosis, a central pain syndrome, a memory disorder, dementia, Alzheimer's disease, an affective disorder, depression, bipolar disorder, anxiety, obsessive/compulsive disorder, Post Traumatic Stress Disorder, an eating disorder, schizophrenia, Tourette's Syndrome, Attention Deficit Disorder, an addiction, autism, epilepsy, a sleep disorder, a hearing disorder (e.g., tinnitus or auditory hallucinations), a speech disorder (e.g., stuttering), and/or one or more other disorders, states, or conditions.

[0027] For example, relative to controlling, influencing, stabilizing, restoring, enhancing, or gaining a motor function, a target neural population may comprise one or more portions of a patient's motor cortex. A neural location at which or a neural region in which stimulation signals are applied or delivered to or through a target neural population may be defined as a stimulation site. Thus, for a target neural population corresponding to the motor cortex, an exemplary stimulation site may comprise a location or region upon the patient's dura mater.

[0028] As another example, relative to controlling, influencing, stabilizing, restoring, or enhancing an auditory function, a target neural population may correspond to one or more portions of a patient's auditory cortex. A stimulation site may comprise an epidural or subdural cortical region

that may facilitate the application, delivery, and/or transfer of stimulation signals to such a target neural population, for example, an epidural site adjacent or proximate to the Sylvian fissure. The application of unipolar stimulation signals to such a stimulation site in accordance with particular embodiments of the invention may increase a likelihood of affecting the target neural population in an intended manner.

[0029] A stimulation site may be identified in accordance with a variety of techniques, including (1) identification of one or more anatomical landmarks; (2) preoperatively (e.g., using Transcranial Magnetic Stimulation) and/or intraoperatively stimulating one or more brain locations to identify or map particular neural regions that induce or evoke a given type of patient response (for example, a movement or a sensation); (3) estimating a location at which the brain may recruit neurons to carry out a given type of neural activity that was previously performed by a damaged portion of the brain; (4) an electrophysiologic signal measurement and/or analysis procedure (e.g., acquisition and/or analysis of EEG, EMG, MEG, coherence, partial coherence, and/or other signals); and/or (5) a neural imaging procedure. In general, the number and/or location of stimulation sites under consideration may depend upon the nature, number, and/or extent of a patient's neurological condition and/or functional deficits.

[0030] Several embodiments of such systems and methods apply or deliver a unipolar, monopolar, or isopolar stimulation signal that may provide enhanced efficacy or efficiency stimulation using a low current level that reduces power consumption and/or mitigates collateral effects. Various embodiments of the present invention may apply or deliver neural stimulation at a subthreshold level or intensity, that is, at a level that raises or generally raises membrane potentials associated with a target neural population while avoiding the generation of a sufficient or statistically significant number of action potentials capable of triggering a neural function corresponding to the target neural population as a result of neural stimulation alone.

[0031] Stimulation systems and methods in accordance with the present invention may be used to treat various neurological conditions and/or facilitate particular types of neurological or functional patient outcomes. Depending upon the nature of a particular condition, neural stimulation applied or delivered in accordance with several embodiments of the invention may affect neural firing likelihoods and/or influence, facilitate, and/or effectuate reorganization of interconnections or synapses between neurons to (a) provide at least some degree of functional recovery and/or functional gain; and/or (b) develop one or more compensatory mechanisms to at least partially overcome a functional deficit or shortcoming. Such reorganization of neural interconnections may be achieved, at least in part, by a change in the strength of synaptic connections through a process that corresponds to a mechanism commonly known as Long-Term Potentiation (LTP). Neural stimulation applied or delivered in accordance with certain embodiments of the invention may alternatively or additionally affect particular neural populations through a process that corresponds to a mechanism commonly known as Long-Term Depression (LTD). Neural stimulation delivered or applied to one or more target neural populations either alone or in conjunction or association with one or more behavioral activities and/or

other types of adjunctive or synergistic therapies (e.g., a drug or chemical substance therapy, a neurotrophic or growth factor therapy, and/or a cell implantation therapy) may facilitate, effectuate, or enhance therapeutic efficacy, for example, through neural plasticity and the reorganization of synaptic interconnections between neurons.

[0032] A. Systems for Applying Electrical Stimulation

[0033] FIG. 1 is a side view of a system for applying electrical stimulation to a neural stimulation site or region according to an embodiment of the invention. In various embodiments, the stimulation site may be upon, essentially upon, or proximate to the surface of the cortex of a patient P. The stimulation system may comprise a stimulus unit 120 and a patient interface that includes a set of electrodes, electrode arrangements and/or electrode assemblies 160 (hereinafter, "electrode assemblies"). In one embodiment, the set of electrode assemblies 160 includes a first electrode assembly 160a and a second electrode assembly 160b. Various alternate embodiments may include additional electrode assemblies, which may be positioned or implanted at or proximate to a set of stimulation sites, or remote from one or more stimulation sites. Electrode assemblies can stimulate different neural regions, e.g., regions carrying out different neural functions and/or regions carrying out neural functions at different locations of the body, including different extremities of the body.

[0034] Depending upon embodiment details, the system may also include a sensing unit 180 (shown schematically) configured to monitor one or more types of patient responses, activities, and/or behaviors. The sensing unit 180 may be further configured to communicate with the stimulus unit 120. The sensing unit 180 may include, for example, electrodes 182 and/or other devices (e.g., an accelerometer or motion detector) configured to sense a patient's neural activity (e.g., an EEG signal), neuromuscular activity (e.g., an EMG signal), behavioral activity (e.g., patient motion), and/or other types of patient activity.

[0035] The stimulus unit 120 generates and outputs stimulation signals, and the set of electrode assemblies 160 facilitates application or delivery of the stimulation signals to the patient P. The stimulus unit 120 may perform, direct, and/or facilitate neural stimulation procedures in a manner that enhances efficacy, mitigates a likelihood of inducing collateral neural activity, and/or conserves power, as described in detail below.

[0036] The stimulus unit 120 may comprise a pulse generator that is implanted into the patient P. In the embodiment shown in FIG. 1, the stimulus unit 120 is an IPG that is implanted in a thoracic, subclavicular, or abdominal location. In other embodiments, the stimulus unit 120 can be an IPG implanted in the patient's skull or just under the patient's scalp. For example, the stimulus unit 120 can be implanted above the patient's neckline at a location in or near the patient's cranium. Examples stimulus units 120 suitable for implantation in a patient's cranium are set forth in U.S. patent application Ser. No. 09/802,808 (previously incorporated by reference), as well as herein with reference to FIGS. 8A through 9B.

[0037] The stimulus unit 120 may comprise a controller 130 and a pulse system 140. The stimulus unit 120 may further comprise a power source, a battery, an energy storage

device, and/or power conversion circuitry (not shown). The controller **130** may include a processor, a memory, and a programmable computer medium. The controller **130** may be implemented as a computer or a microcontroller, and the programmable medium may comprise software, instructions, and/or configuration information loaded into the memory and/or hardware that performs, directs, and/or facilitates neural stimulation procedures in accordance with one or more methods of the present invention.

[0038] The pulse system **140** generates and outputs stimulation signals. **FIG. 2** is a graph illustrating several parameters that may describe, define, or characterize a stimulation signal. A stimulus start time t_0 may define an initial point at which a stimulation signal is applied to a target neural population. In one embodiment, the stimulation signal may be a symmetric or asymmetric biphasic waveform comprising a set or series of biphasic pulses, and which may be defined, characterized, or described by parameters including a pulse width t_1 for a first pulse phase; a pulse width t_2 for a second pulse phase; and a pulse width t_3 for a single biphasic pulse. The parameters can also include a stimulus repetition rate $1/t_4$ corresponding to a pulse repetition frequency; a stimulus pulse duty cycle equal to t_3 divided by t_4 ; a stimulus burst time t_5 that defines a number of pulses in a pulse train; and/or a pulse train repetition rate $1/t_6$ that defines a stimulus burst frequency. Other parameters include a peak current intensity I_1 for the first pulse phase and a peak current intensity I_2 for the second pulse phase. Those skilled in the art will understand that pulse intensity or amplitude may decay during one or both pulse phases, and a pulse may be a charge-balanced waveform. Those skilled in the art will further understand that in an alternate embodiment, pulses can be monophasic or polyphasic.

[0039] In certain embodiments, the pulse system **140** may generate and/or output stimulation signals in accordance with a theta burst pattern. In general, theta burst stimulation may comprise pulse bursts and/or pulse packets separated by quiescent intervals, such that the number of pulse packets per seconds corresponds or approximately corresponds to theta wave frequencies exhibited by the brain. In general, theta wave frequencies may range from approximately 3 to 10 Hz, and more particularly in certain embodiments, 4 to 8 Hz.

[0040] In particular embodiments, the pulse system **140** may vary and/or modulate stimulation signals in one or more manners, for example, in accordance with one or more mathematical operations and/or functions upon or corresponding to particular stimulation signal parameters. Exemplary manners of varying stimulation signals are described in detail in U.S. Application No. 60/588,406, filed on Jul. 15, 2004, entitled "System and Method for Enhancing or Affecting Neural Stimulation Efficiency and/or Efficacy," incorporated herein by reference in its entirety.

[0041] The pulse system **140** may apply or output stimulation signals to, across, or between a first terminal **142a** and a second terminal **142b**. Since a stimulation signal may comprise a time-varying waveform, a relative polarity of the stimulation signal, and hence that of the first and second terminals **142a-b**, may change or vary with time. With respect to outputting one or more stimulation signals having phases that differ in polarity, an anode may be defined as a terminal **142a-b** to which a positive polarity phase within an

initial pulse is first applied. For example, for a stimulation signal comprising a series of biphasic pulses where each pulse includes a positive polarity phase followed by a negative polarity phase, where positive and negative may respectively be defined relative to a zero potential level or a potential offset, an anode may be designated as the particular terminal **142a-b** that first receives a positive polarity phase following the stimulus start time t_0 . A cathode may be defined as a terminal **142a-b** that provides electrical continuity for the stimulation signal delivered through the anodal terminal **142a-b**. The polarity of the cathode may thus be opposite to that of the anode, or neutral. Depending upon embodiment details, a cathode may be defined as a terminal **142a-b** to which a first negative polarity or lower potential phase within an initial pulse is first applied. Those skilled in the art will recognize that the terms anode and cathode could be defined in an opposite or different manner than as defined above, yet such opposite or different definitions would be equivalent, essentially equivalent, or consistent from a mathematical or circuit analysis perspective.

[0042] Depending upon embodiment details, (a) the first terminal **142a** may be configured as an anode, while the second terminal **142b** may be configured as a cathode; (b) the first terminal **142a** may be configured as a cathode, while the second terminal **142b** may be configured as an anode; or (c) the first and second terminals **142a-b** may be selectively or programmably configured as an anode and a cathode, possibly in a predetermined, aperiodic, or pseudo-random time dependent manner. Such anode/cathode selectivity may occur on a subseconds-based, a seconds-based, an hours-based, and/or another type of time domain, and/or may be facilitated by signal selection circuitry (e.g., a multiplexor or a switch matrix) and/or redundant output circuitry within the stimulus unit **120**. In particular embodiments, stimulus periods provided by the stimulus unit **120** can have durations of 30 seconds or less, 10 seconds or less, 2-5 seconds, about one second, and/or less than one second. The stimulus periods can include but are not limited to alternating cathodal and anodal periods, alternating unipolar periods, alternating bipolar periods, and/or periods that alternate between unipolar and bipolar. The electrical potential of the stimulation signal can also alternate between subthreshold levels and suprathreshold levels.

[0043] The first electrode assembly **160a** may be positioned or implanted at a stimulation site that is located upon, essentially upon, or proximate to a target neural population upon, within, or near the patient's cerebral cortex. The first electrode assembly **160a** may comprise a support member **162a** and one or more contacts **164a** carried by the support member **162a**. The support member **162a** may be configured for implantation at a stimulation site upon or at least proximate to the surface of the patient's cortex. The support member **162a**, for example, can be a flexible or rigid substrate that is implanted under the cranium **S** such that the contacts **164a** are positioned upon or adjacent to the dura mater at the stimulation site. In other embodiments, the support member **162a** can be a portion of a cranial screw or a housing that is implanted through the cranium **S**, in a manner identical or analogous to that described in U.S. patent application Ser. No. 10/418,796, which is incorporated herein by reference.

[0044] The first electrode assembly **160a** can have one or more contacts **164a** arranged or positioned in a desired

configuration. For example, the first electrode assembly **160a** may include a single contact **164a**, or a plurality of contacts **164a** arranged as an array, grid, or other pattern. In the embodiment shown in **FIG. 1**, the first electrode assembly **160a** also includes a first lead or link **170a** that electrically couples some or all of the contacts **164a** to the pulse system's first terminal **142a**. The first electrode assembly **160a** may therefore be configured as an anode or a cathode, in accordance with the anodal or cathodal configuration of the first terminal **142a** of the pulse system **140**. Contacts **164a** that are not coupled to the first terminal **142a** at a particular time may electrically float. The first link **170a** may be a wired link or a wireless link. The first electrode assembly **160a** can comprise a cortical neural-stimulation device, such as any of the devices described in U.S. patent application Ser. No. 09/802,808 (previously incorporated herein by reference), and U.S. patent application Ser. No. 10/418,976, which is also incorporated by reference herein.

[0045] The second electrode assembly **160b** can be similar to the first electrode assembly **160a**, or it can be a different type of electrode assembly. The second electrode assembly **160b** may be positioned remotely from the first electrode assembly **160a**. Since the second electrode assembly **160b** provides electrical continuity with respect to the first electrode assembly **160a**, the second electrode assembly **160b** may be defined to reside at a circuit completion site. In the embodiment shown in **FIG. 1**, the second electrode assembly **160b** comprises a separate electrode array including a support base **162b** and one or more contacts **164b**. In accordance with particular embodiment details, the support base **162b** can be configured for positioning at (a) a location or site upon or proximate to the surface of the cortex spaced apart from the stimulation site where the first electrode assembly **160a** is located; (b) a deep brain location; or (c) another area in the body above or below the neck. The second electrode assembly **160b** can include a second link **170b** that couples one or more contacts **164b** (i.e., each contact **164b** that is not electrically floating) to the second terminal **142b** of the pulse system **140**. Thus, the second electrode assembly **160b** may be configured as an anode or a cathode, in accordance with the anodal or cathodal configuration of the pulse system's second terminal **142b**.

[0046] In the embodiment shown, the second electrode assembly **160b**, and more particularly the second electrode assembly's contacts **164b**, are separate or otherwise detached from the first electrode assembly **160a**. Thus, the second electrode assembly's contacts **164b** are not attached to the first electrode assembly **160a**, and the second electrode assembly's contacts **164b** may be movable with respect to the contacts **164a** of the first electrode assembly **160a** before being implanted in the patient. The second electrode assembly **160b** may accordingly be configured to be attached to or implanted in the patient at a location spaced apart from a stimulation site on or proximate to the cortex of the patient where electrical stimulation is to be applied to facilitate and/or effectuate a given neurological or neurofunctional outcome, such as neural plasticity or another type of neural reorganization corresponding to one or more neural populations.

[0047] In the embodiment shown in **FIG. 1**, each contact **164a** of the first electrode assembly **160a** that is coupled to the pulse system's first terminal **142a** (i.e., each non-floating contact **164a**) is biased in accordance with a first signal

polarity. Thus, the pulse system **140** applies an identical polarity signal to each such contact **164a** at any given time. Correspondingly, each intentionally biased or non-floating contact **164b** of the second electrode assembly **160b** is biased in accordance with a second signal polarity, where the second signal polarity is opposite or complementary to the first signal polarity, or neutral, to facilitate electrical current flow between the first and second electrode assemblies **160a-b**.

[0048] Neural stimulation in which both an anode and a cathode are positioned, located, or situated within, essentially directly across, or proximate to a stimulation site may be defined as bipolar stimulation. In contrast, neural stimulation in which one of an anode and a cathode is positioned, located, or situated within or proximate to a stimulation site, while a respective corresponding cathode or anode is positioned, located, or situated remote from the stimulation site to provide electrical continuity may be defined as unipolar, monopolar, or isopolar stimulation. Thus, neural stimulation characterized by a biasing configuration in which an anode and a cathode are positioned, located, or situated in different neurofunctional areas or functionally distinct anatomical regions may be defined as unipolar stimulation. In a unipolar configuration, the pulse system **140** applies an identical polarity signal to each non-floating contact **162a-b** positioned upon or proximate to a stimulation site. Unipolar stimulation may be defined as anodal unipolar stimulation when an anode is positioned upon or proximate to a stimulation site or a target neural population; and as cathodal unipolar stimulation when a cathode is positioned upon or proximate to a stimulation site or a target neural population.

[0049] In several embodiments, the second electrode assembly **160b** is positioned apart or remote from the first electrode assembly **160a** to establish an electric field that passes through deep layers of the cortex and/or other neural regions in a direction that is generally perpendicular or oblique with respect to (a) the first electrode assembly's contacts **164a**; (b) the surface of the cortex under the first electrode assembly **160a**; and/or (c) the cranium of the patient at or proximate to the stimulation site. The electric field, for example, is substantially normal to the first electrode assembly **160a** in the deep layers of the cortex and/or other neural layers beneath the stimulation site.

[0050] **FIGS. 3A and 3B** illustrate a different implementation of a system for applying electrical stimulation to a neural stimulation site according to an embodiment of the invention. In this embodiment, a first electrode assembly **160a** may be implanted in the patient at a stimulation site at least proximate to the surface of the cortex **C** (**FIG. 3B**) over target neurons or a target neural population **N** (**FIG. 3B**). A second electrode assembly **160b** may be positioned at a location in the patient that is spaced apart from the stimulation site, for example, at a location that is above the patient's neck, to establish an electric field orientation or distribution that extends in a desired direction relative to the target neurons **N**. The second electrode assembly **160b** may additionally or alternatively be positioned relative to other neural structures to minimize or mitigate collateral neural activity. The second electrode assembly **160b** can be spaced apart from the patient's brain as shown in **FIG. 3A**, or the second electrode assembly **160b** can be positioned at a different location of the patient's brain as shown in **FIG. 3B**.

[0051] The stimulus unit 120 may provide an output at a first polarity to the non-floating contacts 164a of the first electrode assembly 160a, and provide an output at a second polarity to the non-floating contacts 164b of the second electrode assembly 160b. The first electrode assembly's contacts 164a accordingly provide a unipolar, monopolar, or isopolar bias at the stimulation site upon or proximate to the patient's cortex C. The first polarity may be anodal or cathodal, and the second polarity may respectively be cathodal or anodal (i.e., opposite to the first polarity or neutral). A unipolar signal applied to the first electrode assembly's contacts 164a may establish an electric field that extends through deep layers of the cortex and/or other neural regions along a vector V extending generally perpendicular to, or at least oblique with respect to, the orientation of (a) the first electrode assembly 160a; (b) the surface of the cortex C at or proximate to the stimulation site; and/or (c) the cranium of the patient adjacent to the stimulation site (FIG. 3A).

[0052] Certain systems and/or methods in accordance with the present invention may utilize or rely upon a single electrode assembly having a design that is suitable for providing unipolar stimulation rather than relying upon separate electrode assemblies. FIG. 3C is a schematic illustration of a combined electrode assembly 260 capable of applying or delivering unipolar stimulation to a patient. In one embodiment, the combined electrode assembly 260 includes a support member 262 having a local portion 263a, a remote portion 263b, and a separation portion 263c. The local portion 263a carries a first set of contacts 264a, and the remote portion 263b carries a second set of contacts 264b. The support member 262 may be formed from one or more flexible or generally flexible biocompatible materials (e.g., plastic and/or silicone), and the first and second sets of contacts 264a-b may be formed from one or more biocompatible conductive materials (e.g., Titanium and/or Platinum). Through appropriate couplings to a pulse system's first and second terminals 142a-b (for example, via a first and a second link 170a-b), the first set of contacts 264a may be configured as an anode or a cathode, while the second set of contacts 264b may respectively be configured as a cathode or an anode to facilitate unipolar stimulation.

[0053] The combined electrode assembly 260 may be implanted into a patient such that the local portion 263a resides at, upon, or proximate to a stimulation site, while the remote portion 263b resides at a circuit completion site that is distant or remote from the stimulation site. The separation portion 263c may have a length L that is sufficient to ensure that in a typical patient, an electric field generated at or in the vicinity of the local portion 263a is substantially perpendicular to the patient's cranium, cortical surface, and/or targeted neural tissues (which may include deep cortical layers or regions, as discussed below) beneath the stimulation site. In one embodiment, the value of L may be roughly an order of magnitude greater than the distance between the stimulation site and a target neural population or neural region that is deepest or farthest from the stimulation site. For subdural stimulation, an exemplary value of L may be roughly an order of magnitude greater than approximately 2.5 to 3.0 mm; and for epidural stimulation, an exemplary value of L may be roughly an order of magnitude greater than approximately 4.0 to 6.0 mm.

[0054] The location, depth, and/or spatial boundaries of target neural structures and/or a target neural population may depend upon the nature of a neurological condition or disorder under consideration. The extent to which an electric field reaches, penetrates, and/or travels into or through target neural structures and/or a target neural population may affect neural stimulation efficiency and/or efficacy. An electric field generated by unipolar stimulation may reach or penetrate deeper neural regions at a lower current level than an electric field generated by bipolar stimulation, as further described hereafter.

[0055] FIG. 4 is a schematic illustration showing an exemplary electric field distribution generated by unipolar stimulation using a system in accordance with an embodiment of the invention. In FIG. 4, a first contact 164a is positioned at a stimulation site corresponding to a target neural population, while a second contact (not shown) is positioned distant or remote from the first contact 164a at a different neurofunctional or anatomical region. The first contact 164a may be biased as an anode, for example, and the second contact may be biased as a cathode to establish an electrical potential gradient or difference that facilitates the flow of electrical current (i.e., a net movement of charged particles or ions). A unipolar electric field distribution may be represented as a plurality of field lines 300 that extend through, for example, targeted deep layers of the cortex C and possibly other neural regions in a direction that is at least substantially perpendicular to (1) the surface of the cortex at or proximate to the stimulation site; and/or (2) the first electrode assembly's contacts 164a.

[0056] FIG. 5 is a schematic illustration showing an exemplary electric field distribution generated by bipolar stimulation, which may be selectively produced in accordance with particular embodiments of the invention as further described below. In FIG. 5, a first contact 410a and a second contact 410b are configured to deliver bipolar stimulation to one or more portions of a target neural population. The first and second contacts 410a, 410b are located proximate to each other, within or upon a stimulation site that corresponds to the spatial extent of the target neural population. In a bipolar configuration, contacts 410a-b positioned at and/or near the stimulation site are biased at different polarities. In FIG. 5, the first contact 410a is biased as an anode, while a second contact 410b is biased as a cathode. A bipolar electric field distribution may be represented as a plurality of field lines 400 having field components that are generally parallel to (1) the surface of the cortex at or proximate to the stimulation site; and/or (2) a support member (not shown) configured to carry the first and second contacts 410a-b.

[0057] In general, an electrical potential gradient or difference between an anode and a cathode configured to provide unipolar stimulation exists over a longer or greater distance than an electrical potential gradient between an anode and a cathode configured to provide bipolar stimulation. Thus, an anode to cathode electrical current pathway associated with unipolar stimulation will typically be longer than an electrical current pathway associated with bipolar stimulation. Unipolar stimulation may therefore provide a greater degree of therapeutic efficacy than bipolar stimulation when stimulation of neural regions, structures, and/or projections that are deeper or more distant than those just beneath and/or in the near vicinity of the stimulation site

may be of importance. Moreover, unipolar stimulation may deliver more current to such deeper or more distant neural regions at a lower power level than bipolar stimulation, which may result in greater stimulation efficiency and/or a reduced likelihood of inducing collateral neural activity. Enhanced stimulation efficiency may be important when treating chronic, near-chronic, and/or longer-term conditions, for example, movement disorders or central pain syndrome.

[0058] In addition to or association with the foregoing, an electric field polarity, orientation and/or distribution relative to particular types of neurons, neural projections, neural structures, and/or neurofunctional regions may influence or affect neural stimulation efficiency and/or efficacy. The cortex C may be organized as a set of 6 layers, where layer 1 maintains a boundary corresponding to the cortical surface. Successive cortical layers exist or reside at increasing depths relative to the cortical surface. Thus, layer 6 corresponds to a deepest cortical layer. The thickness or extent of any given cortical layer, and the type, number, and/or size of neurons, neural projections, and/or neural structures therein depends upon the cortical neurofunctional region under consideration.

[0059] Neurons convey input signals along their dendrites toward their cell bodies. Neurons in the cortex C include pyramidal cells 302 and interneurons 304. In the motor cortex, the largest pyramidal cells 320 have soma or cell bodies that reside in deep cortical layer 5. Pyramidal cells 302 have dendrites that project away from their cell bodies into overlying or superficial cortical layers, toward the cortical surface in a manner that is approximately perpendicular or normal to the layer structure of the cortex C. Interneurons 304 have cell bodies that commonly reside in cortical layers 2, 3, and 4, and include dendrites that tend to project away from their cell bodies within the same layer or into an adjacent layer in a manner that is generally lateral or parallel with respect to the layer structure of the cortex C.

[0060] An optimal, near optimal, or desirable electric field orientation for therapeutic neural stimulation may be based upon or determined by the orientation of one or more types of neurons, neural structures, and/or neural projections within or associated with a target neural population N. For example, an electric field that is oriented generally parallel to a main or overall direction in which pyramidal cell dendrites project, that is, generally perpendicular or normal to the cortical layer structure (or equivalently, generally perpendicular or normal to the surface of the cortex C or the cranium), may preferentially influence or exert a more significant effect upon pyramidal cells 302 than interneurons 304, which include dendrites that generally project lateral to the cortical layer structure. In an analogous manner, an electric field that is oriented generally parallel to a typical or overall direction in which interneuron dendrites project, that is, generally parallel or lateral to the cortical layer structure, may preferentially influence or exert a more significant effect upon interneurons 304 than pyramidal cells 302.

[0061] In view of the foregoing, systems and/or methods in accordance with particular embodiments of the invention may apply or deliver stimulation signals having one or more polarities that may enhance a likelihood of facilitating or effectuating a desired neurological and/or functional outcome based upon the types of neurons, neural structures,

and/or neural projections involved in subserving such an outcome. For example, specific embodiments of the invention may apply unipolar stimulation at one or more times to patients experiencing certain types of central pain syndrome. As another example, various embodiments of the invention may apply unipolar stimulation, possibly in conjunction with a behavioral therapy, to patients having functional deficits associated with stroke, traumatic brain injury, cerebral palsy, and/or other disorders (e.g., tinnitus). In certain situations, unipolar stimulation may more effectively facilitate or effectuate neural disinhibition and/or neuroplastic change associated with a target neural population than bipolar stimulation, thereby enhancing the extent to which such patients can recover lost functional abilities and/or develop new abilities.

[0062] Unipolar stimulation may facilitate or effectuate enhanced recovery or development of functional abilities in patients experiencing particular types of neurologic dysfunction when compared to bipolar stimulation. For example, cathodal unipolar stimulation in conjunction or association with a behavioral therapy such as an Activity of Daily Living (ADL) may facilitate or effectuate a greater degree of functional development and/or recovery in a patient experiencing functional deficits associated with stroke, traumatic brain injury, and/or neurological damage than bipolar stimulation either alone or in association or conjunction with such a behavioral therapy. Moreover, such enhanced recovery may occur using lower current or average power levels than would be required for bipolar stimulation, thereby conserving power and/or reducing a likelihood of inducing collateral neural activity.

[0063] Certain systems and/or methods in accordance with the invention may deliver unipolar stimulation during a unipolar stimulation period and bipolar stimulation during a bipolar stimulation period. For example, relative to facilitating or effectuating neuroplasticity, both pyramidal cells 302 and interneurons 304 may play a role in neural reorganization. Thus, a system and/or method may deliver unipolar stimulation to more selectively influence or affect pyramidal cells 302 during a unipolar stimulation period, and deliver bipolar stimulation to more selectively influence or affect interneurons 304 during a bipolar stimulation period. One or more unipolar and/or bipolar stimulation periods may be identical or different in duration, and may occur in a successive or generally successive manner, with or without one or more types of intervening delays, interruptions, or cessations. Any given unipolar stimulation period, bipolar stimulation period, and/or interruption period between unipolar and/or bipolar stimulation periods may correspond to a subseconds-based, a seconds-based, an hours-based, and/or another type of time domain. Depending upon embodiment details, alternation between unipolar and/or bipolar stimulation periods and/or intervals between such periods may temporally occur in a predetermined, aperiodic, or pseudo-random manner. Neural stimulation may be delivered during one or more unipolar and/or bipolar stimulation periods in conjunction or association with one or more adjunctive or synergistic therapies, for example, a behavioral therapy and/or a drug therapy. An adjunctive therapy corresponding to a unipolar stimulation period may be identical to or different from an adjunctive therapy corresponding to a bipolar stimulation period.

[0064] In cortical regions associated with motor control, pyramidal cell axons that project into the spinal cord, brain stem, basal ganglia, and/or other areas may serve as cortical outputs involved in facilitating or controlling movement. In view of manners in which pyramidal cell dendrites and axons project as described above, a given type of unipolar neural stimulation may elicit or generate a patient response or movement at a different (e.g., lower) current level or intensity than bipolar stimulation. Thus, unipolar stimulation may provide or induce an intended or desired effect at a lower current level than bipolar stimulation, thereby conserving power and/or reducing a likelihood of inducing collateral activity. Similarly, unipolar stimulation may facilitate determination of a therapeutic current level using lower amplitude test stimulation signals than required by bipolar stimulation. In some embodiments, a therapeutic current level corresponding to a given type of unipolar stimulation may be mapped to a different type of unipolar stimulation and/or bipolar stimulation in accordance with a mapping function and/or empirical data.

[0065] In addition to the foregoing, certain types of neural cells may exhibit different types of signal conductance properties based upon whether the motion of electrical charges or electrically charged particles (i.e., ions) is toward or away from the axon hillock, the initial axonal region proximate to the cell body through which dendritic inputs are integrated. For instance, in pyramidal cells 302, intracellular ions diffusing toward the axon hillock experience a lower impedance than intracellular ions diffusing toward the dendritic tree, thereby giving rise to an intracellular differential impedance (Neurophysiological Techniques: Applications to Neural Systems, Neuromethods 15, Eds. A. A. Boulton, G. B. Baker, and C. H. Vanderwolf). As a result, anodal unipolar stimulation may affect or influence a neural population, neural structures, and/or neural projections differently than cathodal unipolar stimulation.

[0066] Stimulation signal polarity characteristics may influence or affect an extent to which and/or a manner in which particular neural structures experience a potential difference and/or depolarization or polarization relative to each other, which may affect neural stimulation efficacy and/or efficiency. For example, due to the existence of a potential gradient between a cathode and an anode, a relative dendrite to axon hillock or axon depolarization or hyperpolarization state may give rise to neural stimulation efficacy differences between cathodal unipolar stimulation and anodal unipolar stimulation.

[0067] During cathodal unipolar stimulation, a positive first pulse phase applied at a stimulation site may give rise to an enhanced extracellular concentration of negative ions in a localized region at, just beneath, just around, and/or in the near vicinity of the stimulation site. Such a localized region may correspond, for example, to a small, relatively small, or generally small neural tissue and/or neural structure volume within shallow or superficial layers of the cortex. As a result of the enhanced extracellular concentration of negative ions, dendrites within the localized region may experience an enhanced intracellular concentration of positive ions, thereby shifting the electrical state of such dendrites toward a more depolarized state than, for example, axon hillocks, corresponding to such dendrites.

[0068] In an analogous manner, during anodal unipolar stimulation, a negative first pulse phase applied at a stimulation site may give rise to an enhanced extracellular concentration of positive ions in a localized region at, just beneath, just around, and/or in near proximity to the stimulation site. As a result, dendrites within the localized region may experience an enhanced intracellular concentration of negative ions, thereby shifting the electrical state of such dendrites toward a more hyperpolarized state than axon hillocks corresponding to such dendrites.

[0069] A dendritic potential shift toward a more depolarized state and/or a more hyperpolarized state may affect dendritic signal processing and/or signal generation and/or signal transfer mechanisms. Such a potential shift may affect neural stimulation efficacy, for example, by influencing an extent to and/or manner in which postsynaptic dendrites react or respond to and/or process presynaptic input.

[0070] In certain neural stimulation situations directed toward facilitating and/or effectuating neural plasticity, cathodal unipolar stimulation may increase a likelihood that dendrites within a target neural population respond to and/or process neurofunctionally relevant synaptic input in a manner that enhances a likelihood of generating action potentials that may subserve the development and/or recovery of one or more functional abilities. Neurofunctionally relevant synaptic input may arise from or correspond to an adjunctive or synergistic therapy, for example, a behavioral therapy. The aforementioned neural stimulation situations may include, for example, neural stimulation directed toward rehabilitation of patients experiencing symptoms associated with neurological damage (e.g., arising from stroke or traumatic brain injury), neurodegenerative disorders (e.g., Parkinson's disease, Alzheimer's disease), neuropsychiatric disorders (e.g., depression, OCD), and/or other types of neurologic dysfunction.

[0071] In general, anodal or cathodal unipolar stimulation may be more efficacious and/or efficient than cathodal or anodal unipolar stimulation, respectively, or bipolar stimulation in the context of particular neural stimulation situations, which may include, for example, neural stimulation directed toward traumatic brain injury, cerebral palsy, movement disorders, central pain syndrome, tinnitus, neuropsychiatric disorders, auditory hallucinations, and/or other conditions.

[0072] In particular neural stimulation situations, a likelihood of realizing a given type of neurofunctional outcome may be enhanced through multiple anodal unipolar, cathodal unipolar, and/or bipolar stimulation procedures, which may be applied in a simultaneous, alternating, and/or varying manner. Such stimulation procedures may correspond to identical, generally identical, or different stimulation sites and/or stimulation parameters (e.g., pulse repetition frequency, first phase pulse width, a peak current and/or voltage amplitude or magnitude, theta burst characteristics, a waveform variation and/or modulation function, and/or other parameters) depending upon the nature of a patient's neurologic dysfunction, patient condition, and/or embodiment details. Moreover, any given stimulation procedure and/or an interval between stimulation procedures may correspond to a subseconds-based, a seconds-based, an hours-based, and/or another type of time period or domain. In one embodiment, before, during, and/or after one or more por-

tions of a cathodal stimulation procedure directed toward a first target neural population, an anodal unipolar stimulation procedure may be directed toward a second target neural population. The first and second target neural populations may reside in the same or different brain hemispheres.

[0073] FIG. 6 is a side view of a system for applying electrical stimulation to a surface site on the cortex in accordance with an embodiment of the invention. In this embodiment, the system includes a stimulus unit 520 and a patient interface including a first electrode assembly 560a and a second electrode assembly 560b. The stimulus unit 520 can include a controller 530 and a pulse system 540 similar to the controller 130 and pulse system 140 of the stimulation unit 120 described above with reference to FIG. 1. The stimulus unit 520 can also include a housing 580 that is configured to be implanted or otherwise attached to the patient.

[0074] The first electrode assembly 560a can be similar to the first electrode assembly 160a described above with reference to FIG. 1. The first electrode assembly 560a can accordingly include a support member 562a configured to be implanted proximate to the cortex of the patient and at least one surface contact 564a. The surface contacts 564a can be coupled to a first terminal 542a of the stimulus unit 520 by a link 570.

[0075] The second electrode assembly 560b can be a separate item or element attached to the stimulus unit 520, or the second electrode assembly 560b can be an integral component of the stimulus unit 520. The second electrode assembly 560b, for example, can be a conductive portion of the housing 580 of the stimulus unit 520. In other embodiments, the entire housing 580 of the stimulus unit 520 can be a conductive material that defines the second electrode assembly 560b, or a portion of the housing 580 can be covered with an appropriate type of dielectric or insulating material or be composed of such a material to limit the conductive surface area of the second electrode assembly 560b to a desired shape or area. In still other embodiments, the second electrode assembly 560b is a separate set of contacts attached to the housing 580. The second electrode assembly 560b is coupled to a second terminal 542b of the pulse system 540.

[0076] The system shown in FIG. 6 operates by electrically biasing the surface contacts 564a at an identical polarity, and biasing the second electrode assembly 560b with an opposite or neutral polarity. For example, the system may be configured to deliver anodal unipolar stimulation to a stimulation site by biasing the surface contacts 564a as an anode, and biasing the second electrode assembly 560b as a cathode. It will be appreciated that the surface contacts 564a could alternatively be biased as a cathode while the second electrode assembly 560b is biased as an anode. The system shown in FIG. 6 accordingly provides a unipolar signal at the stimulation site on or proximate to the surface of the cortex of the patient.

[0077] Another aspect of the invention may involve configuring a neural stimulation system to induce a desired electrical field and/or current density at or proximate to a stimulation site as well as a remote circuit completion site. In one embodiment, the aggregate surface area of conductive surfaces that provide circuit completion or electrical continuity remote or generally remote from the stimulation site

(e.g., contacts 164b carried by a second electrode assembly 160b or 560b, or an exposed conductive surface of a housing 580) is approximately 200%-1500% of the aggregate surface area of conductive surfaces that apply or deliver stimulation signals to one or more stimulation sites (e.g., contacts 164a or 564a carried by a first electrode assembly 160a or 560a), and more specifically 250%-450%. The larger conductive surface area corresponding to the circuit completion site reduces the current density at the current completion site compared to the stimulation site; this is expected to reduce collateral neural activity, muscle activity, and/or patient sensation in the region of the circuit completion site.

[0078] FIG. 7 is a side view illustrating a system for applying electrical stimulation to a surface site on the cortex in accordance with another embodiment of the invention. In this embodiment, the system includes the stimulus unit 120, the second electrode assembly 160b, and a surface electrode assembly 660. The surface electrode assembly 660 can comprise an array including a support member 662 configured to be implanted at the cortical stimulation site, a plurality of first surface contacts 664 carried by one portion of the support member 662, and a plurality of second surface contacts 665 carried by another section of the support member 662. The first surface contacts 664 are coupled to the first link 170a to electrically couple the first surface contacts 664 to the first terminal 142a of the stimulus unit 120. The second surface contacts 665 can be coupled to the second link 170b to electrically couple the second surface contacts 665 to the second terminal 142b of the stimulus unit 120. The first surface contacts 664 can be biased as an anode, and the second surface contacts 665 can be biased as a cathode, or vice versa. In an alternate embodiment, the second surface contacts 665 can be connected to a separate link to be coupled to a third terminal of the stimulus unit 120. The second surface contacts 665 can accordingly be biased independently of either the first surface contacts 664 or the second electrode assembly's contacts 164b.

[0079] The embodiment of the system illustrated in FIG. 7 can provide a combination of unipolar and bipolar stimulation. For example, the first surface contacts 664 can be biased at a first polarity while the second surface contacts 665 or the return contacts 164b are biased at a second polarity. In another embodiment, the second surface contacts 665 are coupled to another terminal on the stimulus unit 120 so that the second surface contacts 665 can be biased separately from the return contacts 164b. This particular embodiment operates in a manner in which the first surface contacts 664 and the second electrode assembly's contacts 164b can be biased while not biasing the second surface contacts 665 during a unipolar stimulation period, and then the first surface contacts 664 can be biased at the first polarity while the second surface contacts 665 are biased at the second polarity during a bipolar stimulation period. The stimulus unit 120 can alternate unipolar stimulation and bipolar stimulation periods according to a desired sequence to provide a combination of unipolar and bipolar stimulation.

[0080] FIG. 8A is an isometric view and FIG. 8B is a cross sectional view of a system for applying electrical stimulation to a surface site on or proximate to the cortex in accordance with another embodiment of the invention. In one embodiment, the system comprises a support member 800 that may carry a control unit 830 and a pulse system

840, plus a first electrode assembly **860a** and a second electrode assembly **860b**. The support member **800** may include a housing **802** configured for implantation into the skull **890**, and an attachment element **804** configured for connection to the skull **890** by fasteners, an adhesive, and/or an anchor.

[0081] The first electrode assembly **860a** may comprise a biasing element **862** that carries a first set of electrical contacts **864a**. The biasing element **862** may be formed using a soft, conformable, and/or compressible biocompatible material. In one embodiment, the first electrode assembly **860a** is coupled to a first terminal **842a** of the pulse system **840**. The second electrode assembly **860b** may comprise one or more exposed conductive portions of the housing **802** and/or the attachment element **804**, and/or a second set of electrical contacts **864b** that are carried by the housing **802** and/or the attachment element **804**. The second electrode assembly **860b** may be coupled to a second terminal **842b** of the pulse system **840**. Depending upon embodiment details, the pulse system's first and second terminals **842a-b** may be configured as an anode and a cathode, possibly in a selectable or programmable manner. Additionally, configuration or establishment of an anodal and a cathodal relationship between the pulse system's first and second terminals **842a-b** may occur in a predetermined, aperiodic, or pseudo-random time-varying manner.

[0082] The support member **800** may be implanted into or through a craniotomy that is above a stimulation site, such that one or more portions of the biasing element **862** and/or the first set of contacts **864a** reside upon, essentially upon, or proximate to the stimulation site. Following implantation, the attachment element **804** may be covered by the patient's scalp **892**. The first electrode assembly **860a** may be biased in accordance with a first polarity to apply or deliver unipolar stimulation to a target neural population, neural projections, and/or neural structures associated with the stimulation site. The second electrode assembly **860b** may be biased in accordance with a second polarity to provide electrical continuity for stimulation signals delivered by the first electrode assembly **860a**. In such a configuration, an electrical current pathway between the first and second electrode assemblies **842a-b** may include one or more portions of the patient's cortex, one or more neural regions below the cortex, vasculature, and/or portions of the patient's scalp. In order to eliminate, essentially eliminate, or minimize electrical current flow from the first electrode assembly **860a** to the second electrode assembly **860b** along a current path that includes an interface between the skull **890** and the edge of the housing **802** and/or the attachment element **804**, one or more portions of the housing **802** and/or the attachment element **804** may comprise or include an insulating material that forms a nonconductive seal or barrier between the skull **890** and the housing **802** and/or the attachment element **804**.

[0083] FIG. 8C is a cross sectional view of a system for applying electrical stimulation to a surface site on or proximate to the cortex according to another embodiment of the invention. Relative to FIGS. 8A and 8B, like reference numbers indicate like elements. In the embodiment shown in FIG. 8C, the first electrode assembly **860a** includes a first subset of contacts **865** coupled to the pulse system's first terminal **842a**. Additionally, the pulse system **840** includes a signal selection module **880** capable of selectively cou-

pling (1) a second subset of contacts **866** to the first or second terminal **842a-b** of the pulse system **830**; and/or (2) the second electrode assembly **860b** to the pulse system's second terminal **842b** (in a manner that avoids simultaneous coupling of the second subset of contacts **866** to the first and second terminals **842a-b**). The embodiment shown in FIG. 8C may thus be configured to provide unipolar stimulation by biasing the first subset of contacts **865** and possibly the second subset of contacts **866** at a first polarity, and biasing the second electrode assembly **842b** at a second polarity; or bipolar stimulation by biasing the first subset of contacts **865** at a first polarity and the second subset of contacts **866** at a second polarity.

[0084] FIG. 9A is a schematic illustration of a system for applying electrical stimulation to a surface site on or proximate to the cortex in accordance with another embodiment of the invention. Relative to FIGS. 8A, 8B, and 8C, like reference numbers indicate like elements. In one embodiment, the system comprises a support member **800** that carries a controller **830**, a pulse system **840**, and a local electrode assembly **860**. The system may further include at least one remote electrode assembly **960**. The support member **800** may include a housing **802** and an attachment element **804** as described above.

[0085] The local electrode assembly **860** may comprise a biasing element **862** that carries a first set of contacts **864**. In one embodiment, the local electrode assembly **860** is coupled to the pulse system's first terminal **842a**. The remote electrode assembly **960** may comprise a support member **962** that carries a second set of contacts **964**, and may have a structure analogous to one or more types of electrodes described in U.S. patent application Ser. No. 10/877,830, which is incorporated herein by reference. Alternatively, the remote electrode assembly **960** may comprise a cranial screw or peg type electrode as described in U.S. patent application Ser. No. 10/418,796 (previously incorporated herein by reference); or a depth, deep brain, or other type of electrode. In certain embodiments, the remote electrode assembly **960** may provide an active or aggregate conductive surface area that is greater than an active or aggregate conductive surface area associated with the local electrode assembly **860** in a manner analogous to that described above. The remote electrode assembly **960** may be coupled to the pulse system's second terminal **842b** by a link **970**. Depending upon embodiment details, the pulse system's first and second terminals **842a-b** may be configured as an anode and a cathode, possibly in a selective, programmable, deterministic, and/or pseudo-random manner.

[0086] The support member **800** may be implanted into or through a craniotomy that is above a stimulation site in a manner analogous to that described above. The remote electrode assembly **960** may be implanted or positioned distant or remote from the support member **800**. The remote electrode assembly **960**, for example, may be positioned upon or beneath the patient's skin at an anatomical location that is above or below the patient's neck; or within the patient's cranium at a cortical, subcortical, or deep brain location that is distant, distinct, or remote from the local electrode assembly **860**. The local electrode assembly **860** may be biased in accordance with a first signal polarity, and the remote electrode assembly **960** may be biased in accordance with a second signal polarity to provide unipolar stimulation.

[0087] **FIG. 9B** is a schematic illustration of a system for applying electrical stimulation to a surface site on or proximate to the cortex in accordance with another embodiment of the invention. Relative to **FIG. 9A**, like reference numbers indicate like elements. The embodiment shown in **FIG. 9B** includes a first and a second remote electrode assembly **960a-b**, which may be identical, essentially identical, or different in structure. Any given remote electrode assembly **960a-b** may comprise an electrode of a type indicated above. Depending upon embodiment details, the first and/or the second remote electrode assembly **960a-b** may provide an active or aggregate conductive surface area that is greater than an active or aggregate conductive surface area associated with the local electrode assembly **860** in a manner analogous to that described above. The first and second remote electrode assemblies **960a-b** are respectively coupled to the pulse system's second terminal **842b** by a first and a second link **970a-b**.

[0088] The embodiment shown in **FIG. 9B** may further include a signal selection module **980** that facilitates selectable or programmable coupling of the first and/or second remote electrode assembly **960a-b** to the pulse system's second terminal **842b**. Depending upon embodiment details and/or the nature of the patient's neurological condition, only one of the first and second remote electrode assemblies **960a-b** may be coupled to the pulse system's second terminal **842b** at any given time; or the first and second remote electrode assemblies **960a-b** may be coupled to the second terminal **842b** simultaneously.

[0089] In various embodiments, the support member **800** may be implanted at a stimulation site in a manner analogous to that described above. The first and second remote electrode assemblies **960a-b** may be respectively positioned or implanted at a first and a second anatomical location that is distant, remote, or distinct from the stimulation site. The local electrode assembly **860** may be biased in accordance with a first signal polarity, while one or both of the remote electrode assemblies **960a-b** may be biased in accordance with a second signal polarity at any given time to provide unipolar stimulation.

[0090] The use of multiple remote electrode assemblies **960a-b** positioned at different anatomical locations may provide multiple current pathways through which neural stimulation may affect or influence particular target cortical and/or subcortical neural populations, neural structures, and/or neural projections, possibly in an alternating or time-dependent manner. For example, unipolar stimulation delivered or applied along or with respect to a first current pathway may be directed toward affecting neural activity in a first hemisphere of the brain, while unipolar stimulation applied with respect to a second current pathway may be directed toward affecting neural activity in a second hemisphere of the brain. Neural activity in each hemisphere may influence the development, recovery, and/or retention of functional abilities, possibly through neuroplastic mechanisms. In certain embodiments, one or more stimulation parameters such as stimulation signal frequency, amplitude, and/or polarity may differ or vary in accordance with a current pathway that is active or under consideration at any given time.

[0091] One or more embodiments described above may be modified to include or exclude elements or features

described in association with other embodiments, for example a signal selection module **880, 980**. Additionally or alternatively, particular embodiments may include multiple local electrode assemblies positioned at multiple stimulation sites, in conjunction with one or more remote electrode assemblies positioned distant from such stimulation sites to provide electrical continuity for unipolar stimulation.

[0092] B. Methods for Applying Electrical Stimulation

[0093] **FIGS. 10-11** are flow charts illustrating various methods for applying neural stimulation to a stimulation site in accordance with the present invention. **FIG. 10**, more specifically, illustrates a method **1000** including a start procedure **1002**, at least one unipolar stimulation procedure **1004**, and a decision procedure **1008**. The unipolar stimulation procedure **1004** includes establishing an electrical field by applying an electrical signal having an identical first signal polarity to a first set of contacts located at a stimulation site while applying a second signal polarity to a second set of contacts that is spaced apart or remote from the stimulation site. The unipolar stimulation procedure **1004** may involve the application of anodal unipolar stimulation and/or cathodal unipolar stimulation to the patient, possibly in a manner that increases or enhances a likelihood or rate of patient functional recovery and/or development. Moreover, the unipolar stimulation procedure **1004** may involve the application or delivery of stimulation signals at a subthreshold and/or a suprathreshold level relative to the generation of a statistically and/or functionally significant number of action potentials in one or more target neural populations. The unipolar stimulation procedure **1004** may also involve the application of theta burst stimulation signals during one or more time periods.

[0094] The unipolar stimulation procedure **1004** can be performed using any of the systems set forth above with respect to **FIGS. 1-9B**. The second set of contacts can be located apart from the stimulation site along a vector that passes through deep layers of the cortex and/or other neural regions in a direction that is oblique, and generally approximately normal, with respect to the first set of contacts at the stimulation site. The unipolar stimulation procedure **1004**, for example, may involve applying a cathodal and/or an anodal signal to a set of active surface contacts **164a** to restore or at least partially recover speech, movement, and/or other functions that have been impaired by stroke or other brain damage.

[0095] An optional or alternative embodiment of the method **1000** can further include at least one bipolar stimulation procedure **1006** in which a first set of contacts at a stimulation site are biased at a first signal polarity, while a second set of contacts at a stimulation site are biased at a second signal polarity. The bipolar stimulation procedure **1006** may be performed in a manner identical or analogous to that described above, and may involve the delivery of stimulation signals at a subthreshold and/or a suprathreshold level. The bipolar stimulation procedure **1006** may also involve the application of theta burst stimulation signals during one or more time periods.

[0096] The decision procedure **1008** may decide whether the stimulation has been of sufficient or adequate duration and/or effect. In particular embodiments, the decision procedure **1008** may involve monitoring or measuring patient progress and/or functional capabilities through one or more

standardized measures, tests, or tasks. Such standardized measures may include or be based upon, for example, a Fugl-Meyer Assessment of Sensorimotor Impairment; a National Institute of Health (NIH) Stroke Scale; a Stroke Impact Scale (SIS); an ADL scale; a Quality of Life (QoL) scale; physical measures such as grip strength or finger tapping speed; a neuropsychological testing battery; a walking, movement, and/or dexterity test; a behavioral test; a language test; a comprehension test; and/or other measures of patient functional ability. In certain embodiments, the decision procedure **1008** may alternatively or additionally involve an electrophysiological signal acquisition and/or analysis procedure, and/or a neural imaging procedure (e.g., MRI, fMRI, or PET). The decision procedure **1008** may direct the method **1000** to apply either a unipolar stimulation procedure **1004** and/or a bipolar stimulation procedure **1006** depending upon the particular characteristics of the therapy and/or the nature or extent of the patient's neurofunctional condition. One or more stimulation sites and/or stimulation parameters (e.g., pulse repetition frequency, first phase pulse width, peak current and/or voltage amplitude, theta burst characteristics, a waveform variation and/or modulation function, and/or other parameters) corresponding to particular unipolar and/or bipolar stimulation procedures **1004**, **1006** may be identical, generally identical, or different depending upon the nature of a patient's neurologic dysfunction, patient condition, and/or embodiment details. The method **1000** may further include a termination procedure **1010** that is performed based upon the outcome of the decision procedure **1008**.

[0097] **FIG. 11** illustrates a method **1100** in accordance with another embodiment of the invention. In one embodiment, the method **1100** includes a start procedure **1102**, a unipolar stimulation procedure **1104**, and possibly a first adjunctive or synergistic therapy procedure **1106**. The unipolar stimulation procedure **1104** may involve the application or delivery of anodal and/or cathodal unipolar stimulation signals to the patient, possibly in a manner that increases or enhances a likelihood and/or rate of patient functional recovery and/or development. Moreover, the unipolar stimulation procedure **1104** may involve subthreshold and/or suprathreshold stimulation, and/or theta burst stimulation during one or more time periods.

[0098] The unipolar stimulation procedure **1104** and the first adjunctive therapy procedure **1106** can be performed concurrently or serially depending upon the nature and/or extent of a patient's neurologic dysfunction, patient condition, and/or embodiment details. The first adjunctive therapy procedure **1106** may comprise a behavioral therapy procedure that can include a physical therapy, an activity of daily living, an intentional use of an affected body part, a speech therapy, a vision therapy, an auditory task or therapy (e.g., an auditory discrimination task), a reading task, a memory task, a visualization, imagination, or thought task, and/or another type of task or therapy. A subthreshold unipolar stimulation procedure **1104** may be performed concurrent with a first behavioral therapy procedure **1106** to enhance or maximize a likelihood generating action potentials that may subserve the development and/or recovery of one or more functional abilities.

[0099] The method **1100** may additionally include a first decision procedure **1108** that may decide whether the unipolar stimulation procedure **1104** and/or the first adjunctive

therapy procedure **1106** have been of sufficient or adequate duration and/or effect. The first decision procedure **1108** may involve measurement or assessment of patient status, progress, and/or functional capabilities using one or more standardized measures, tests, or tasks; an electrophysiological signal acquisition and/or analysis procedure; and/or a neural imaging procedure. If additional unipolar stimulation and/or adjunctive therapy is warranted, the method **1100** may continue, resume, or restart a unipolar stimulation procedure **1104** and/or a first adjunctive therapy procedure **1106**.

[0100] In certain embodiments, the method **1100** may further include a bipolar stimulation procedure **1110**, and/or a second adjunctive or synergistic therapy procedure **1112**. The bipolar stimulation procedure **1110** may involve the application or delivery of stimulation signals at a subthreshold and/or suprathreshold level, and may possibly involve theta burst stimulation at one or more times. The bipolar stimulation procedure **1110** may be directed toward the same, essentially the same, or different target neural structures, target neural projections, and/or target neural populations than the unipolar stimulation procedure **1104**. Thus, the bipolar stimulation procedure **1110** may deliver or apply stimulation signals to the same or a different stimulation site than the unipolar stimulation procedure **1104**, either in the same and/or a different brain hemisphere. For example, both the unipolar and bipolar stimulation procedures **1104**, **1110** may deliver stimulation signals to identical or essentially identical portions of a patient's motor cortex; or the unipolar stimulation procedure **1104** may apply stimulation signals to portions of the patient's motor cortex, while the bipolar stimulation procedure **1110** may apply stimulation signals to portions of the patient's premotor cortex or another region of the brain.

[0101] The second adjunctive therapy procedure **1112** may involve, for example, a drug therapy and/or a behavioral therapy that is identical or essentially identical to or different from a therapy associated with the first adjunctive therapy procedure **1106**. The second adjunctive therapy procedure **1112** may involve, for example, a visualization procedure such as thinking about performing one or more types of motions and/or tasks, while the first adjunctive therapy procedure **1106** may involve attempting to actually perform such motions and/or tasks.

[0102] Depending upon the nature and/or extent of a patient's neurologic dysfunction, patient condition, and/or embodiment details, the bipolar stimulation procedure **1110** and the second adjunctive therapy procedure **1112** may be performed concurrently or serially, in a manner analogous to that described above for the unipolar stimulation procedure **1104** and the first adjunctive therapy procedure **1106**. Moreover, the bipolar stimulation procedure **1110** and/or the second adjunctive therapy procedure **1112** may precede or follow the unipolar stimulation procedure **1104** and/or the first adjunctive therapy procedure **1106** in either a generally continuous or an interrupted manner.

[0103] The method **1100** may further include a second decision procedure **1114** that may decide whether the bipolar stimulation procedure **1110** and/or the second adjunctive therapy procedure **1112** have been of sufficient or adequate duration and/or effect. The second decision procedure **1114** may involve measurement or assessment of patient status,

progress, and/or functional capabilities using one or more standardized measures, tests, or tasks; an electrophysiological signal acquisition and/or analysis procedure; and/or a neural imaging procedure. If additional bipolar stimulation and/or adjunctive therapy is warranted, the method **1100** may continue, resume, or restart a bipolar stimulation procedure **1110** and/or a second adjunctive therapy procedure **1112**. Finally, the method **1100** may include a termination procedure **1116** that may be performed based upon an outcome of the first and/or second decision procedure **1108**, **1116**.

[0104] Depending upon embodiment details, a method **1100** may comprise a number of anodal unipolar, cathodal unipolar, and/or bipolar stimulation procedures **1104**, **1110**, where the number, duration of, and/or time between such procedures and/or the particular stimulation sites to which such procedures are directed may be identical, essentially identical, or different. Moreover, one or more stimulation signal parameters (e.g., pulse repetition frequency, first phase pulse width, peak current and/or voltage amplitude, theta burst characteristics, a waveform variation and/or modulation function, and/or other parameters) corresponding to particular unipolar and/or bipolar stimulation procedures **1104**, **1110** may be identical, generally identical, or different depending upon the nature of a patient's neurologic dysfunction, patient condition, and/or embodiment details.

[0105] In certain embodiments, one or more procedures described herein may form portions of a limited duration treatment program, in a manner analogous to that described in U.S. application Ser. No. 10/606,202, incorporated herein by reference. In accordance with various embodiments of the present invention, a limited duration treatment program may apply or deliver unipolar stimulation, and possibly bipolar stimulation, to a patient for a limited period of time to facilitate or effectuate complete, essentially complete, significant, or partial rehabilitation, restoration, or functional healing of or recovery from a neurological condition such as a neurological malfunction and/or a neurologically based deficit or disorder. Depending upon the extent or nature of the patient's neurological condition and/or functional deficits, a limited duration treatment program may last, for example, a number of weeks, months, or possibly one or more years.

[0106] From the foregoing, it will be appreciated that specific embodiments of the invention have been described herein for purposes of illustration, but that various modifications may be made without deviating from the spirit and scope of the invention. For example, aspects of the invention described in the context of particular embodiments can be combined or eliminated in other embodiments. Accordingly, the invention is not limited except as by the appended claims.

1-75. (canceled)

76. A system for applying electrical stimulation to a cortex of a patient, comprising:

an implantable housing having a first portion and a second portion;

a pulse generator carried by the implantable housing;

a plurality of first electrical contacts carried by the first portion of the housing so as to be positioned at a cortical stimulation site of the patient located at least

approximately at or below an inner surface of the patient's skull when the housing is implanted, the first electrical contacts being generally fixed laterally relative to the first portion of the housing, and electrically biasable to different levels; and

at least one second electrical contact carried by the second portion of the housing so as to be positioned at least approximately at or above an outer surface of the patient's skull and beneath the patient's scalp when the housing is implanted.

77. The system of claim 76 wherein the first and second portions of the housing face in generally opposite directions.

78. The system of claim 76 wherein at least one of the first electrical contacts is fixed in a direction generally normal to the first portion of the housing.

79. The device of claim 76 wherein at least one of the first electrical contacts is movable in a direction generally normal to the housing to apply a force to adjacent tissue when the housing is implanted.

80. The device of claim 76 wherein the housing includes a forcing element to which at least one of the first electrical contacts is coupled, the forcing element being positioned to apply a force to the first electrical contact in a direction generally normal to the housing.

81. The system of claim 76 wherein the at least one second electrical contact includes multiple second electrical contacts that have generally fixed lateral positions relative to the housing.

82. The system of claim 76 wherein the first portion of the housing includes a first surface and the second portion of the housing includes a second, oppositely facing surface, and wherein the first electrical contacts are accessible from the first surface and the second electrical contacts are accessible from the second surface.

83. The system of claim 76, further comprising an attachment element carried by the housing and attachable to the skull.

84. The system of claim 76 wherein the pulse generator is programmed to provide electrical signals at subthreshold levels.

85. The system of claim 76 wherein the first electrical contacts project from the housing in a direction generally normal to the housing.

86. The system of claim 76, further comprising a switching circuit having at least one switch coupled to the pulse generator and among the first electrical contacts to apply electrical power to a subset of one or more selected first electrical contacts.

87. The system of claim 76 wherein the switching circuit is coupled to the second electrical contact and is changeable between a first configuration in which a pair of the first electrical contacts operate in a bipolar manner, and a second configuration in which the second electrical contact and one of the first electrical contacts operate in a unipolar manner.

88. The device of claim 76 wherein at least one of the first electrical contacts has a generally blunt shape and is positioned to bear against at least one of a dura mater and a pia mater of the patient.

89. A system for applying electrical stimulation to a cortex of a patient, comprising:

an implantable housing having a first portion and a second portion;

a pulse generator carried by the implantable housing;

a first electrical contact carried by the first portion of the housing so as to be positioned at a cortical stimulation site of the patient located at least approximately at or below an inner surface of the patient's skull when the housing is implanted, the first electrical contact being generally fixed laterally relative to the first portion of the housing; and

a second electrical contact carried by the second portion of the housing so as to be positioned at least approximately at or above an outer surface of the patient's skull and beneath the patient's scalp when the housing is implanted.

90. The system of claim 89 wherein the first and second electrical contacts are electrically biasable to different levels.

91. The system of claim 89 wherein the first electrical contact is one of a plurality of first electrical contacts.

92. The system of claim 89 wherein the first and second portions of the housing face in generally opposite directions.

93. The system of claim 89 wherein at least one of the first electrical contacts is fixed in a direction generally normal to the first portion of the housing.

94. The system of claim 89 wherein the second electrical contact is one of multiple second electrical contacts that have generally fixed lateral positions relative to the housing.

95. The device of claim 89 wherein the first electrical contact is movable in a direction generally normal to the housing to apply a force to adjacent tissue when the housing is implanted.

96. The device of claim 89 wherein the housing includes a forcing element to which at least one of the first electrical contacts is coupled, the forcing element being positioned to apply a force to the first electrical contact in a direction generally normal to the housing.

97. The system of claim 89 wherein the first portion of the housing includes a first surface and the second portion of the housing includes a second, oppositely facing surface, and wherein the first electrical contacts are accessible from the first surface and the second electrical contacts are accessible from the second surface.

98. The system of claim 89, further comprising an attachment element carried by the housing and attachable to the skull.

99. The system of claim 89 wherein the pulse generator is programmed to provide electrical signals at subthreshold levels.

100. The system of claim 89 wherein the first electrical contact projects from the housing in a direction generally normal to the housing.

101. The system of claim 89 wherein the first electrical contact is one of a plurality of first electrical contacts, and wherein the system further comprises a switching circuit having at least one switch coupled to the pulse generator and among the first electrical contacts to apply electrical power to a subset of one or more selected first electrical contacts.

102. The system of claim 89 wherein the switching circuit is coupled to the second electrical contact and is changeable between a first configuration in which a pair of the first electrical contacts operate in a bipolar manner, and a second configuration in which the second electrical contact and one of the first electrical contacts operate in a unipolar manner.

103. The device of claim 89 wherein at least one of the first electrical contacts has a generally blunt shape and is positioned to bear against at least one of a dura mater and a pia mater of the patient.

104. A system for applying electrical stimulation to a cortex of a patient, comprising:

an implantable housing;

a pulse generator carried by the implantable housing;

a first electrical contact electrically coupled to the pulse generator so as to be positioned at a cortical stimulation site of the patient located at least approximately at or below an inner surface of the patient's skull when the housing is implanted; and

a second electrical contact carried by the housing and having a fixed position relative to the housing so as to be positioned at least approximately at or above an outer surface of the patient's skull and beneath the patient's scalp when the housing is implanted.

105. The system of claim 104 wherein the first electrical contact is coupled to a lead and is laterally movable relative to the housing.

106. The system of claim 104 wherein the first electrical contact includes a plurality of first electrical contacts that are electrically biasable to different levels.

107. The system of claim 104 wherein the first electrical contact is generally fixed laterally relative to the housing.

108. The system of claim 104 wherein the first and second electrical contacts are electrically biasable to different levels.

109. The device of claim 104 wherein the first electrical contact is movable in a direction generally normal to the housing to apply a force to adjacent tissue when the housing is implanted.

110. The device of claim 104 wherein the housing includes a forcing element to which the first electrical contact is coupled, the forcing element being positioned to apply a force to the first electrical contact in a direction generally normal to the housing.

111. The system of claim 104 wherein the at least one second electrical contact includes multiple second electrical contacts that have generally fixed lateral positions relative to the housing.

112. The system of claim 104, further comprising an attachment element carried by the housing and attachable to the skull.

113. The system of claim 104 wherein the pulse generator is programmed to provide electrical signals at subthreshold levels.

114. The device of claim 104 wherein the first electrical contact has a generally blunt shape and is positioned to bear against at least one of a dura mater and a pia mater of the patient.

115. A method for implanting a cortical stimulation device, comprising:

providing an implantable housing carrying a pulse generator, the pulse generator being electrically coupled to a first electrical contact, the housing carrying a second electrical contact;

forming a hole in a patient's skull;

moving the first electrical contact into the hole and positioning the first electrical contact at a cortical

stimulation site of the patient located at least approximately at or below an inner surface of the patient's skull; and

placing the implantable housing in the hole so as to position the second electrode at least approximately at or above an outer surface of the patient's skull and beneath the patient's scalp, with the second electrode having a fixed position relative to the housing.

116. The method of claim 115 wherein forming a hole in the patient's skull includes forming the hole to extend through the patient's skull.

117. The method of claim 115 wherein placing the implantable housing includes placing the implantable hous-

ing while the first electrical contact has a laterally fixed position relative to the housing, and wherein moving the first electrical contact into the hole and placing the implantable housing in the hole are performed simultaneously.

118. The method of claim 115 wherein moving the first electrical contact includes moving the first electrical contact while the first electrical contact is connected to the housing with a flexible lead.

119. The method of claim 115, further comprising applying a subthreshold stimulation signal to the patient via the first electrical contact.

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